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Defect Interactions at Metal-Ceramic Interfaces in Thin Film Multilayers

Presented by: Amit Misra

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Los Alamos, NM 87545**

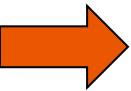
¹Now at ANSTO, Sydney; ²Now at MIT, Cambridge, MA; ³EMPA, Switzerland.

**QMN-3, Idaho Falls, ID,
June 2012**



<http://cmime.lanl.gov/>

Outline



Motivation: Thin film multilayer as model geometry for studying defect interactions at interfaces as a function of length scale and interface structures

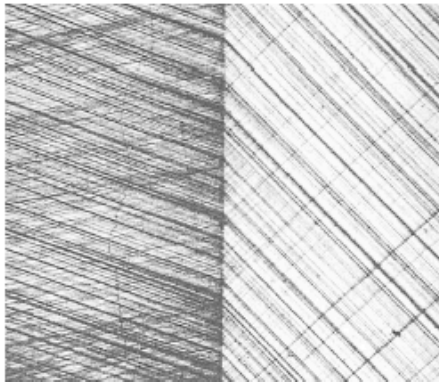
Mechanical Behavior: Dislocation and crack interactions with metal-ceramic interfaces

Radiation Damage: Point defect interactions with metal-ceramic interfaces

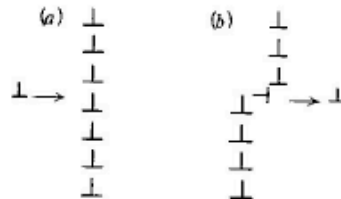
Interface phenomena are ubiquitous in structural materials behavior

(Strength, Intergranular fracture, Radiation damage, Stress corrosion cracking, Creep,)

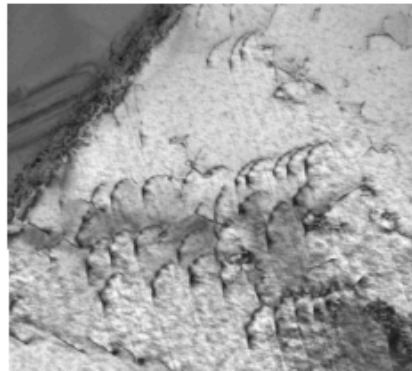
- Interfaces / Boundaries serve as dislocation sources, sinks, storage and barriers
- In this way, interfaces are known, qualitatively, to influence mechanical properties



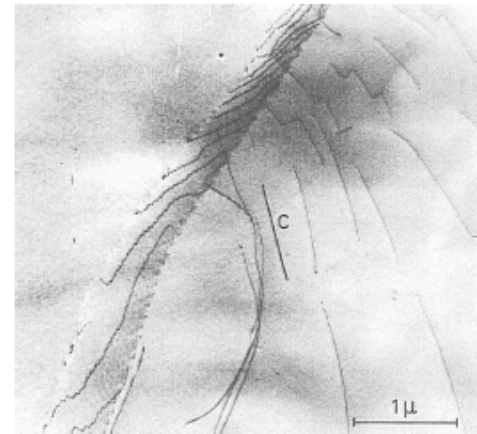
Activation of secondary slip to accommodate plastic compatibility



A tilt boundary before and after cutting by a lattice dislocation



Pile-up of dislocations against a grain boundary



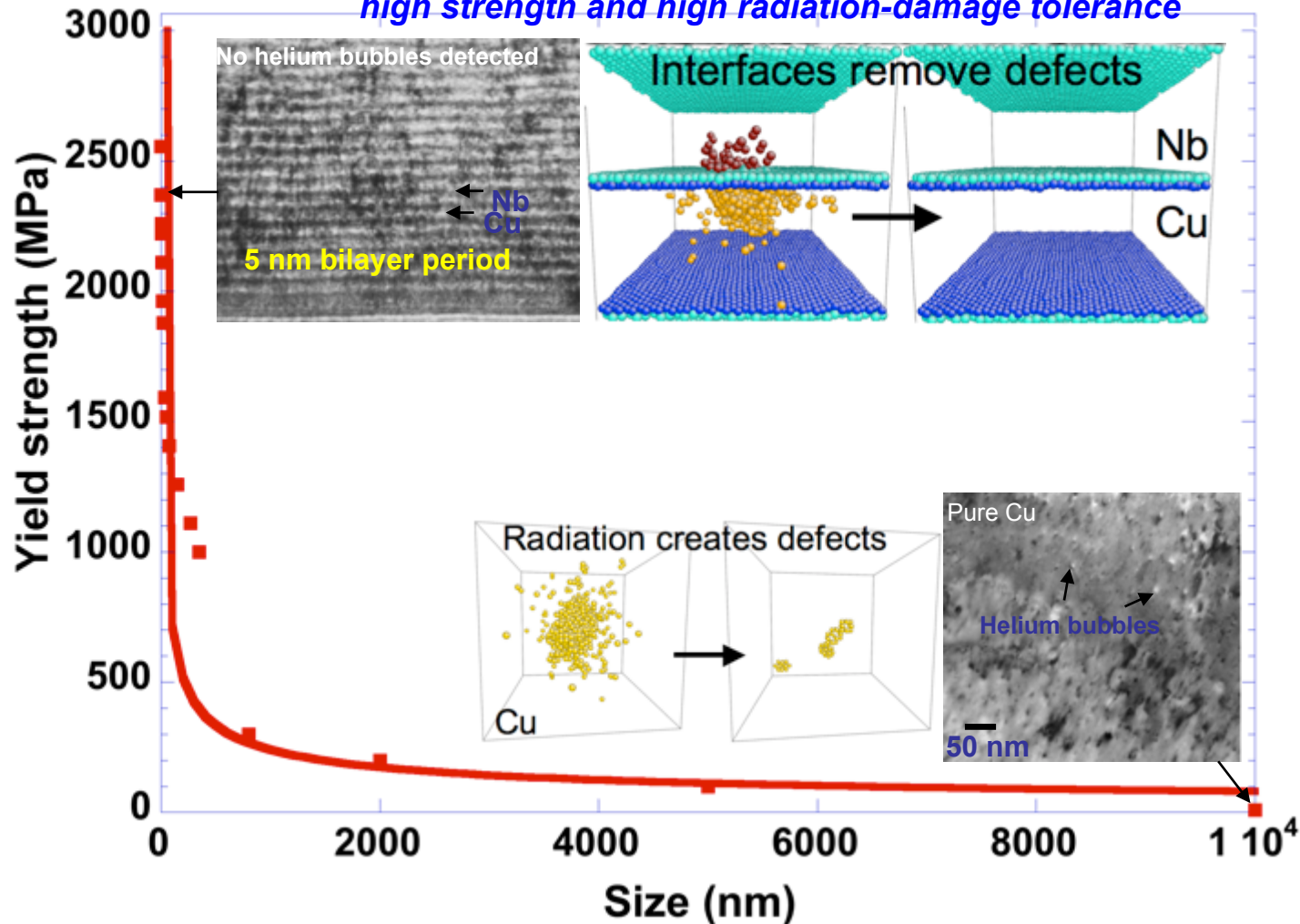
Interaction of inverse pile-ups at a boundary leads to annihilation

J.P. Hirth, Met. Trans., 3 (1972) 3047-3067.

Interface-dominated behavior in nanostructured and nanocomposite materials

Bulk material systems: “interfaces play a role”;
Thin films or self-supported nano material systems: “interfaces-dominate”

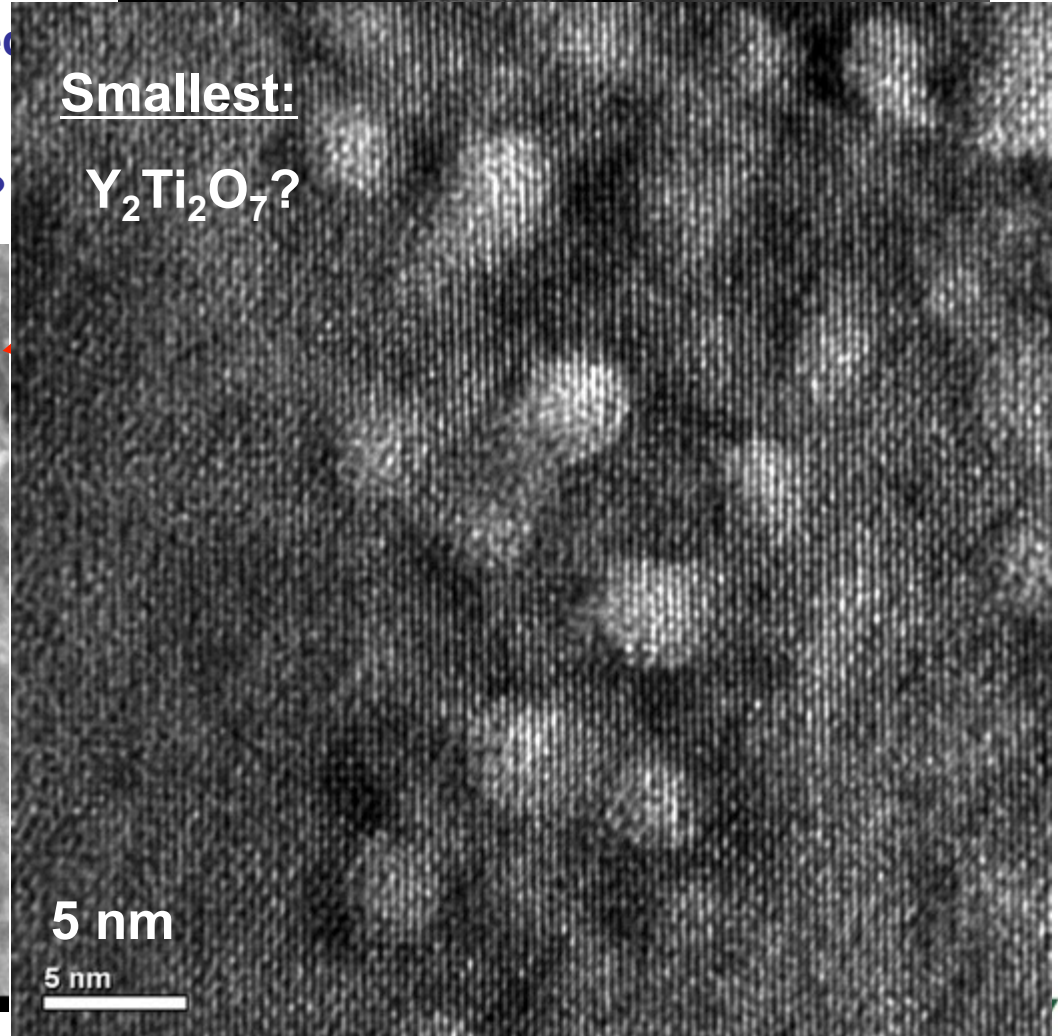
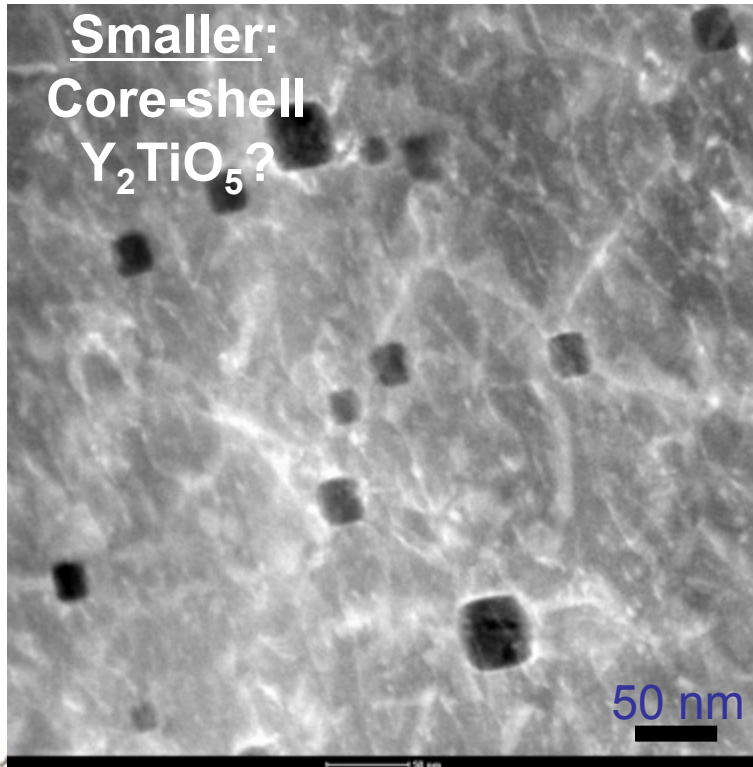
*Interfaces act as obstacles to slip and sinks for radiation induced defects =>
design materials containing the right kind of interfaces to achieve
high strength and high radiation-damage tolerance*



Oxide-dispersion-strengthened (ODS) steels show high creep resistance and reduced swelling under irradiation due to metal-oxide interfaces. The complexity of these nanostructured systems calls for model systems to explore the physics of defect interactions at interfaces.

U14YWT (ball milled and HIP-ed) - Fe - 14% Cr - 3%W - 0.4% Ti - 0.3% Y_2O_3 (Wt. %)
Three types of particles observed:

- (a) 100-200 nm particles - faceted
- (b) 20-50 nm particles - square
- (c) ~5 nm particles - spherical?



Use of model material systems in the study of the role of atomic structure of interfaces in radiation damage

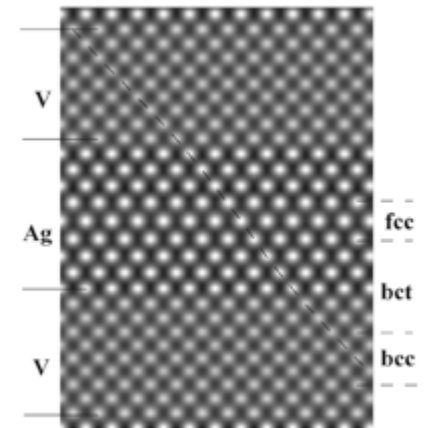
Interface Geometry

In order to determine the atomic arrangement in the interface, we must know the orientation relationship (parallel planes and directions) and habit plane.

e.g., Kurdjumov-Sachs orientation relationship:
 $\{111\}_{\text{fcc}} // \{110\}_{\text{bcc}} // \text{interface}; <110>_{\text{fcc}} // <111>_{\text{bcc}}.$

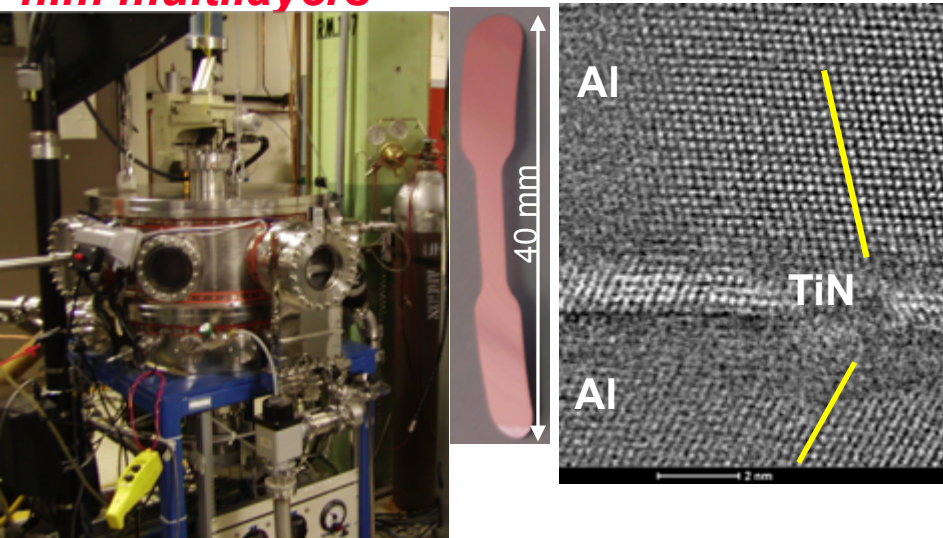
Atomistic modeling is crucial in understanding the point defect-interface interactions in terms of the atomic structure of the interface
=> Study materials for which accurate interatomic potentials.

For experiments, sample geometry should allow high-resolution examination of the interface structure
=> e.g., bi-layer or multi-layer thin films

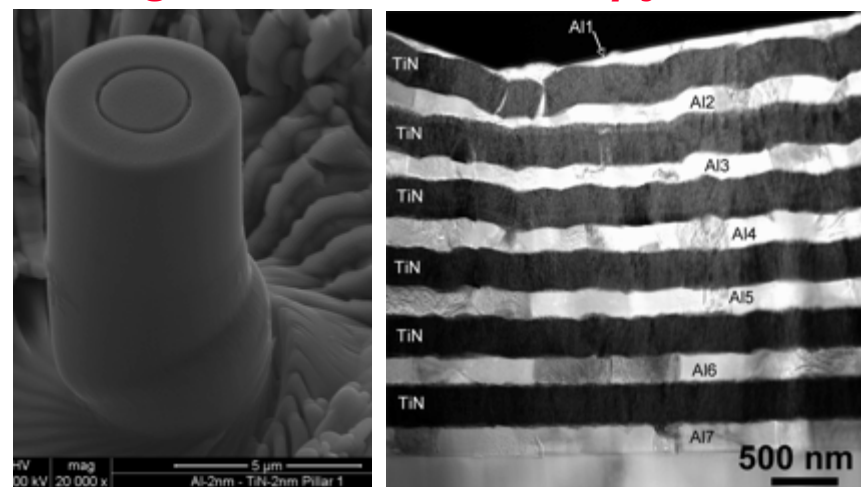


Experiments and Atomistic Modeling on Model Systems Enable Fundamental Understanding of Defect Interactions at Interfaces

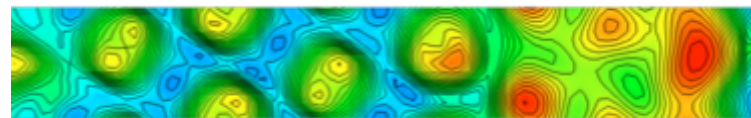
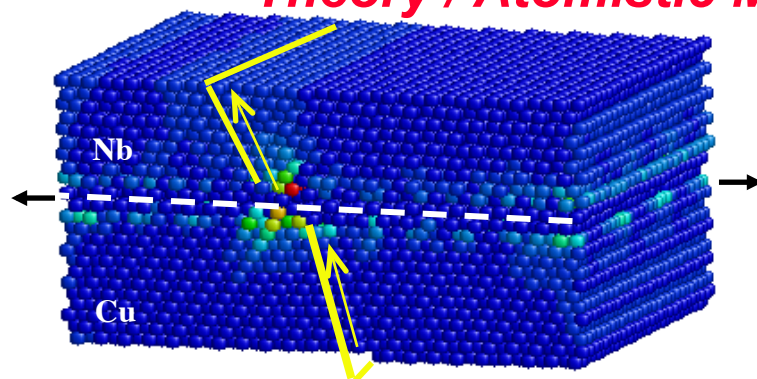
Synthesis of thin film multilayers



Characterization: Nanomechanical testing, electron microscopy, XRD



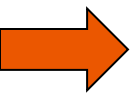
Theory / Atomistic Modeling



*first principles calculations
of metal/ceramic interfaces*

Outline

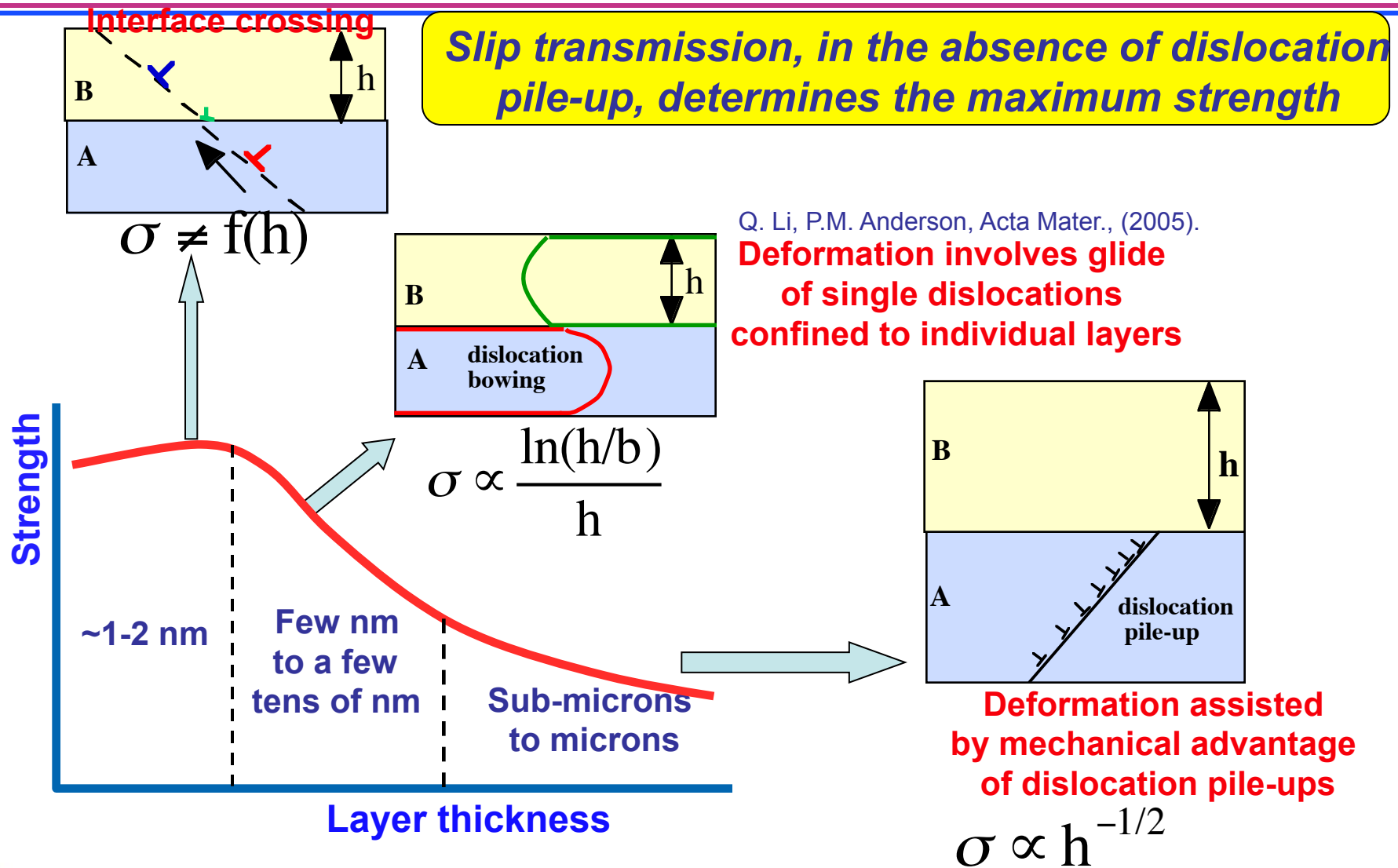
Motivation: Thin film multilayer as model geometry for studying defect interactions at interfaces as a function of length scale and interface structures



Mechanical Behavior: Dislocation and crack interactions with metal-ceramic interfaces

Radiation Damage: Point defect interactions with metal-ceramic interfaces

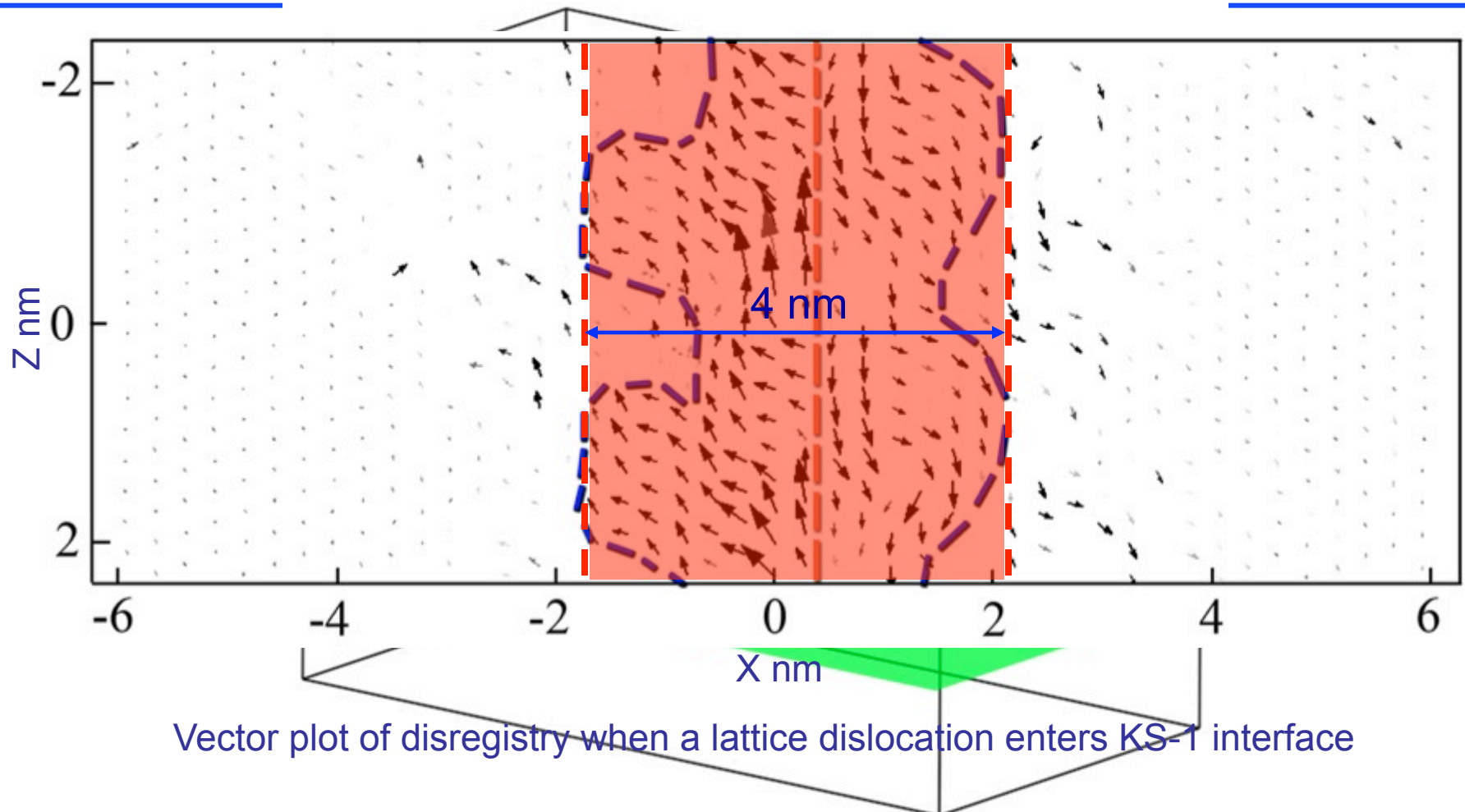
Layer thickness dependence of deformation mechanisms



Q. Li, P.M. Anderson, Acta Mater., (2005).

(A. Misra, R.G. Hoagland, J.P. Hirth, Acta Mater., (2005).

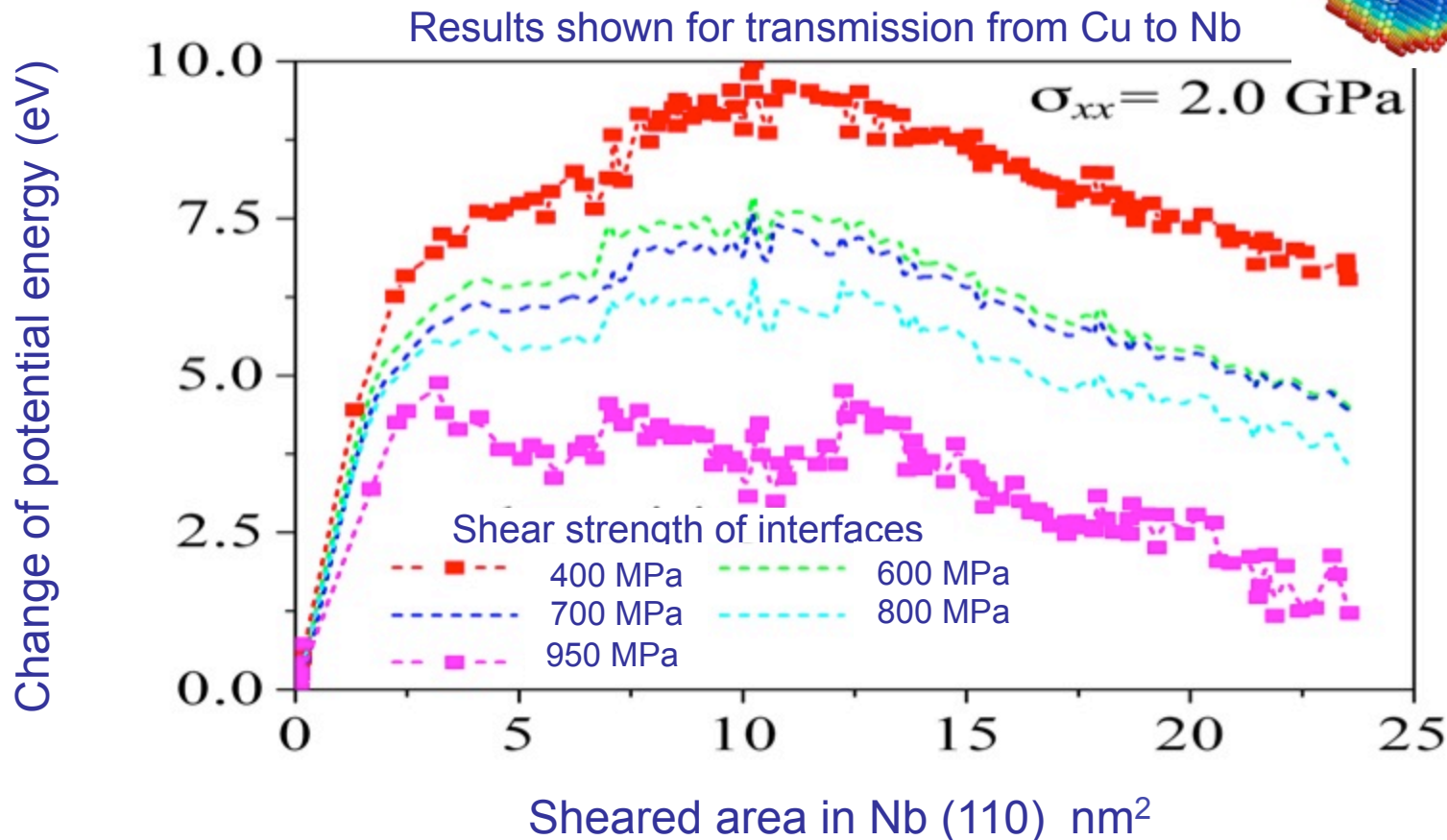
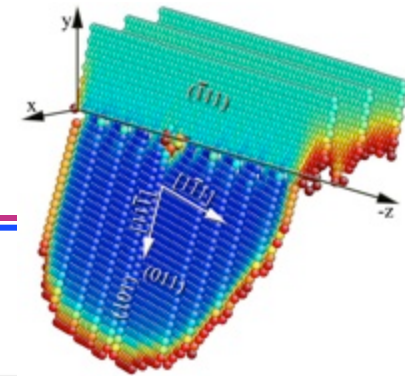
“Weak” interfaces are readily sheared under the stress field of a glide dislocation and serve as strong barriers to slip transmission



Vector plot of disregistry when a lattice dislocation enters KS-1 interface

A Cu/Nb KS₁ model in which one of the Shockley dislocations has entered the interface.

Total work done in nucleating a critical size dislocation loop from the interface depends on the interface shear strength



Strong dependence on interface shear resistance: weaker interfaces have higher barriers for loop nucleation.

Nano-scale Metal-Ceramic Multilayers

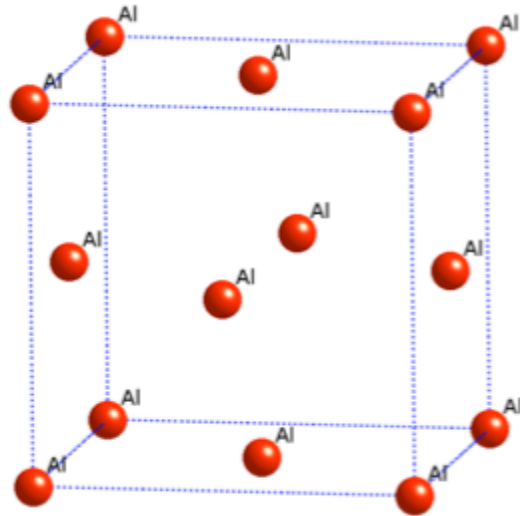
Can we achieve *high strengths* accompanied by *appreciable ductility* ?

What is the effect of *volume fraction* changes on the mechanical properties of these nano-composite materials?

Can the ceramic (TiN) phase *co-deform* with the Al layers under certain conditions?

Crystal Structures of Al and TiN

Al - FCC

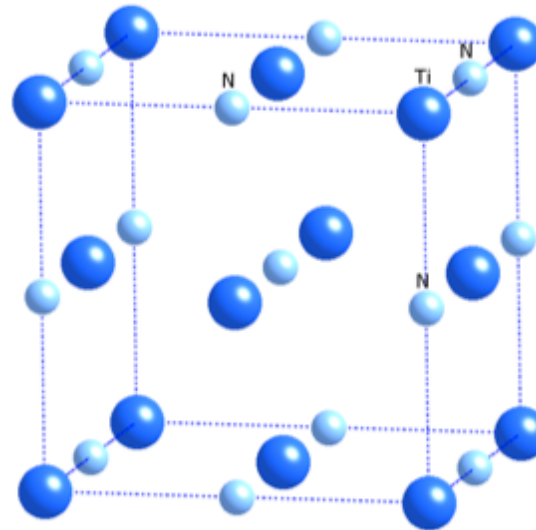


$$a = 4.049 \text{ \AA}$$

$$E = 70.6 \text{ GPa}$$

$$H = 0.5 \text{ GPa (300nm)}$$

TiN - NaCl structure



$$a = 4.235 \text{ \AA}$$

$$E = 251 \text{ GPa}$$

$$H = 18\text{-}21 \text{ GPa (Bulk)}$$

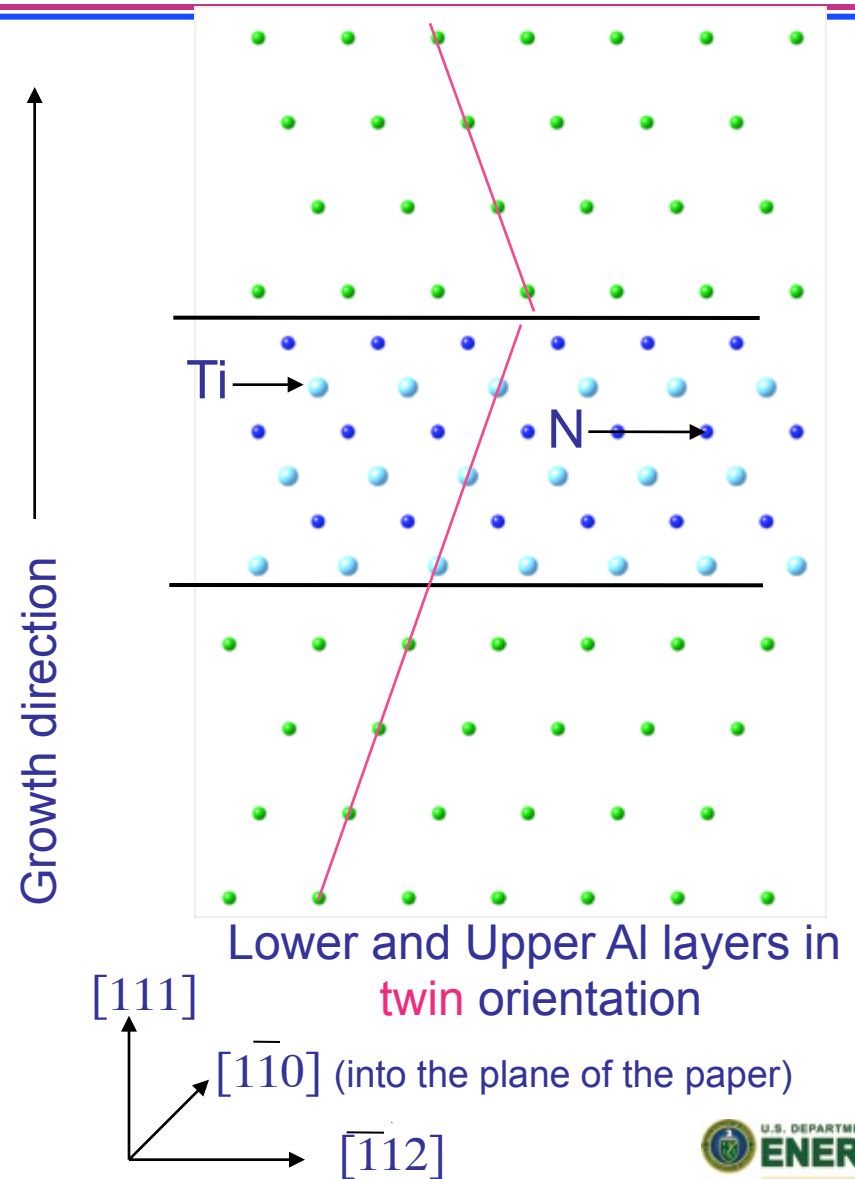
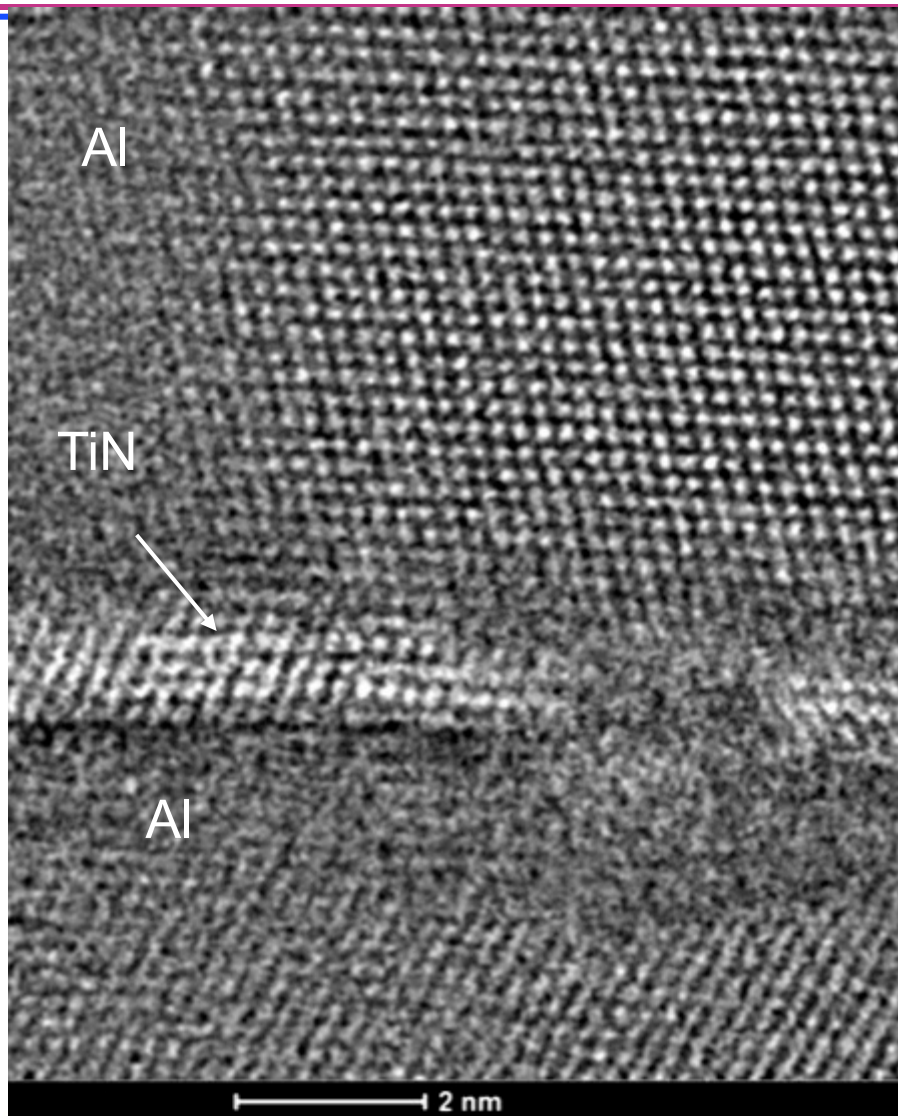
Orientation relationship - mostly cube on cube with {111} interface plane

Recent results from metal (Al) – ceramic (TiN) multilayers that are presented in the following slides

- **Unusual growth of Al layers in twin orientation (interface effect)**
- **Dependence of interface shear strength on interface chemistry**
- **High strength and co-deformability but only when both layers**
- **High work hardening rate that increases with decreasing size**
- **Indentation fracture: toughening due to flow of Al into TiN cracks**

Twinning in Nanolayered Al/TiN/Al

D. Bhattacharyya, X.Y. Liu, A. Genc, H.L. Fraser, R.G. Hoagland and A. Misra, *Applied Physics Letters*, **96**, 093113 (2010).



Ab initio DFT calculation: benchmark

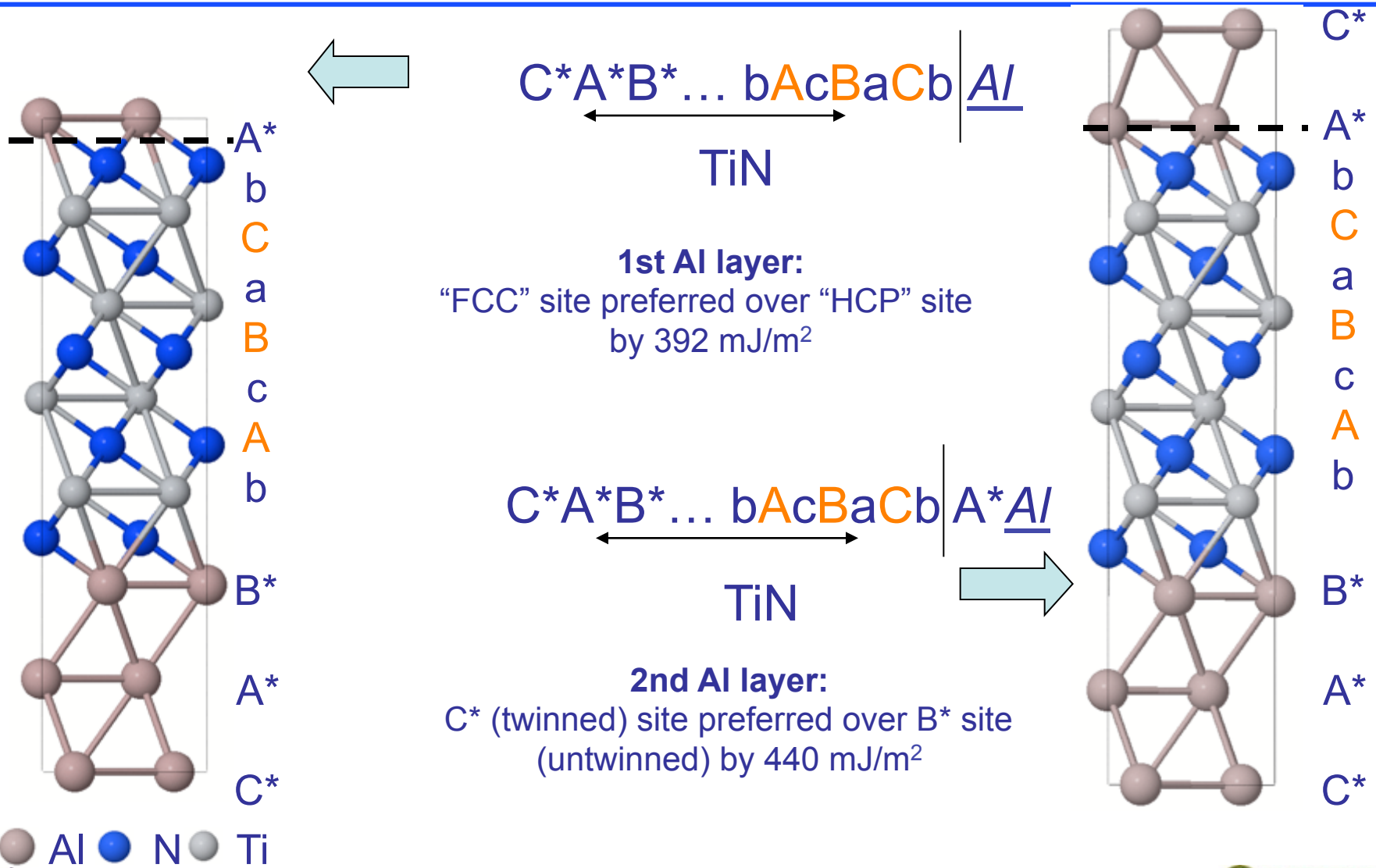
High precision DFT-GGA calculations using VASP



- Monkhorst-Pack k -points sampling 18x18x18 and 7x7x7 mesh for Al and TiN
- Perdew-Burke-Ernzerhof (PBE) generalized gradient approximation (GGA) functional, and projector-augmented wave (PAW) method
- Planewave cutoff energy 300 eV and 500 eV for Al and TiN
- A series of incremental shear strains were applied to the suitably chosen unit cell to calculate the ideal shear strength: simple shear – cell shape and volume fixed; pure shear – allow relaxation of cell shape and volume

	Al		TiN	
	DFT	Expt.	DFT	Expt.
Lattice parameter (Å)	4.04	4.03	4.24	4.24
Bulk modulus (GPa)	76	79	277	288
C_{11} (GPa)	114	108	639	625
C_{12} (GPa)	61	62	139	165
C_{44} (GPa)	25	28	160	163

DFT calculations show that Al growth on N-terminated TiN(111) surface favors twinned structure



Al growth layers on TiN(111) surface

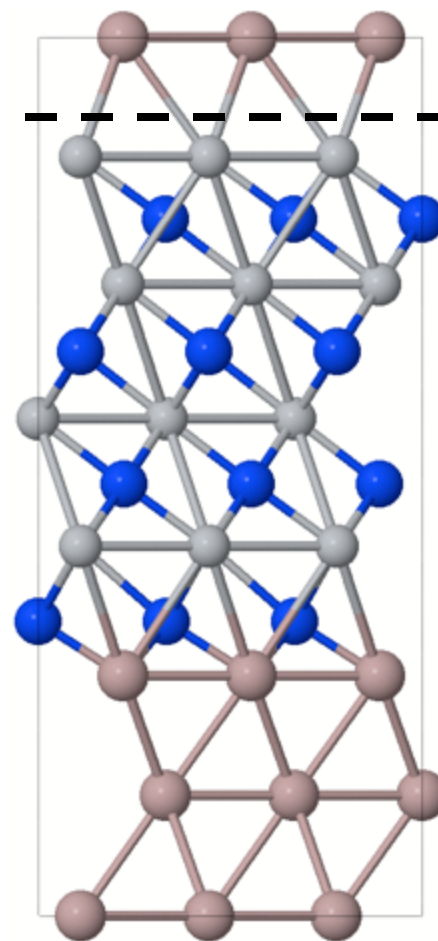
DFT prediction of Ti termination effect

1st Al layer:

“FCC” site preferred over “HCP”
site by 97 mJ/m²

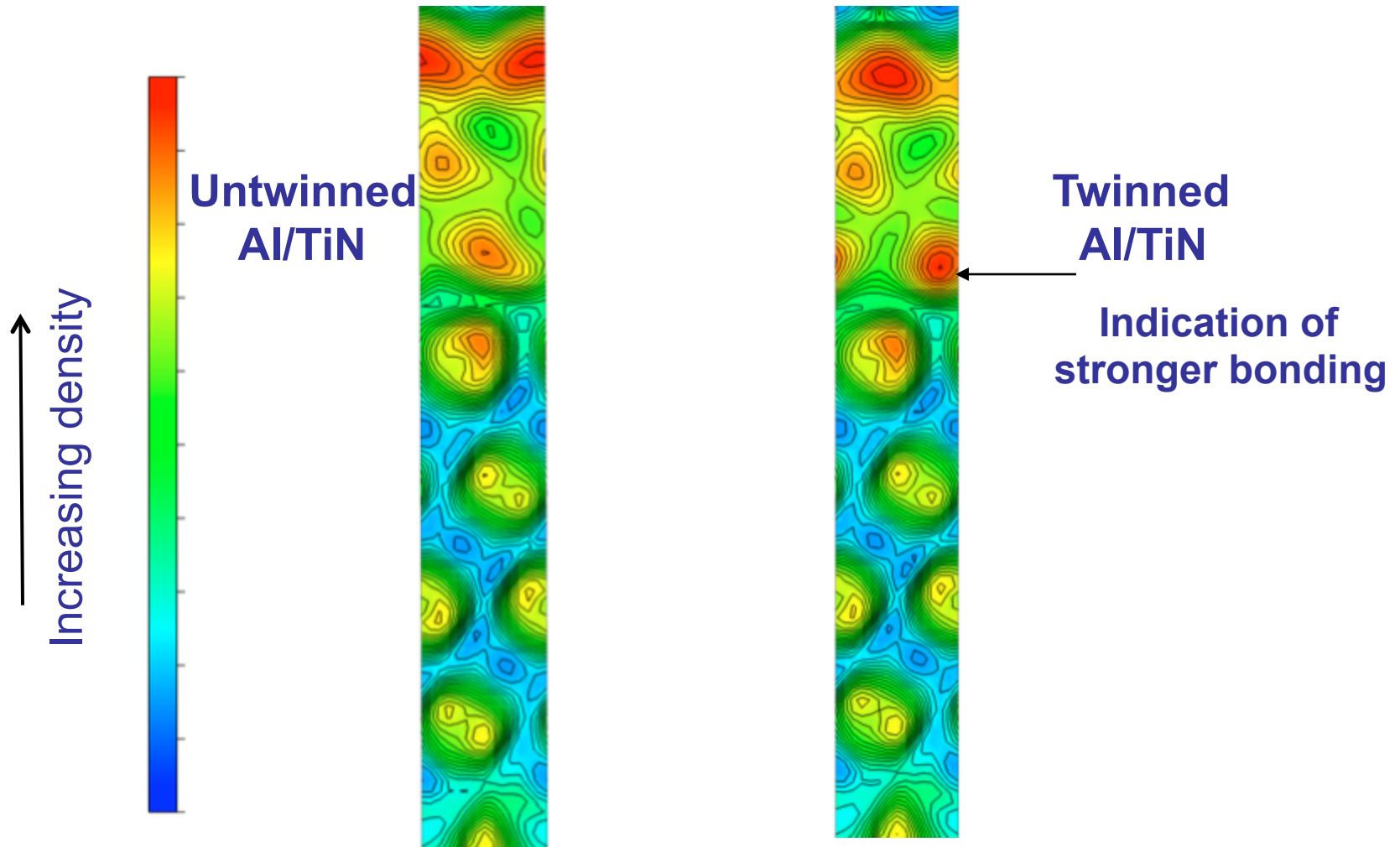
2nd Al layer:

Twinned and untwinned
configurations are essentially
degenerate in total energies,
indicating that there is **no energetic
preference** of twinned Al layers.



● Al ● N ● Ti

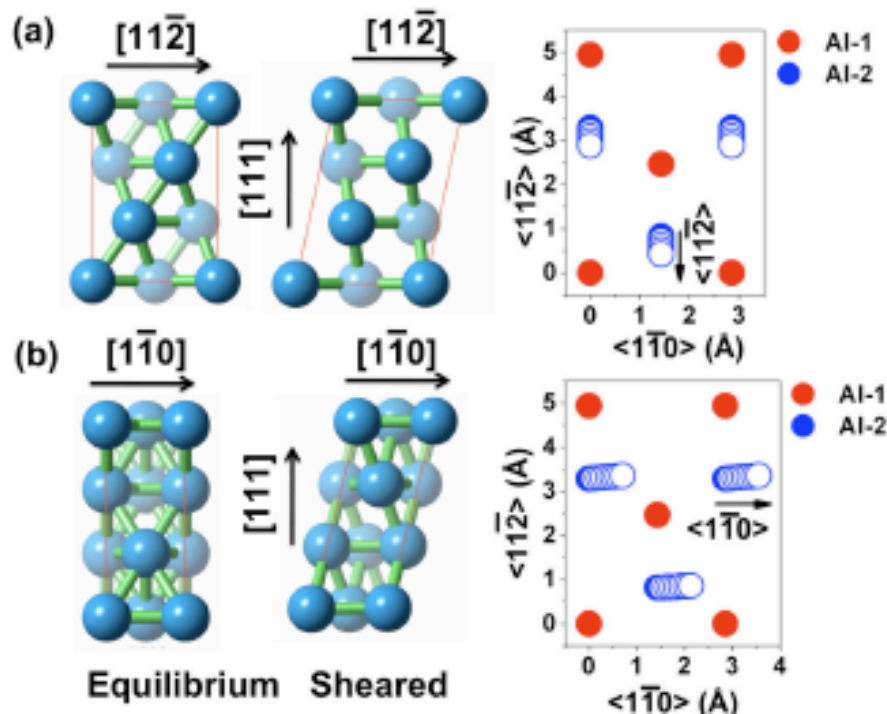
Electron Density at Al/TiN Interfaces



Ideal Shear Strength of Al

	Simple shear		Pure shear		
Shear systems	Shear strength (GPa)	Shear strain	Shear strength (GPa)	Shear strain	% Volume Increase
$\{111\}\langle 11\bar{2}\rangle$	4.2 (3.7*)	0.20	3.2 (2.9*)	0.19	1.9
$\{111\}\langle 1\bar{1}0\rangle$	6.9	0.27	4.3 (3.5**)	0.25	4.1

Difference in ideal shear strength values may be due to GGA and PBE used by.



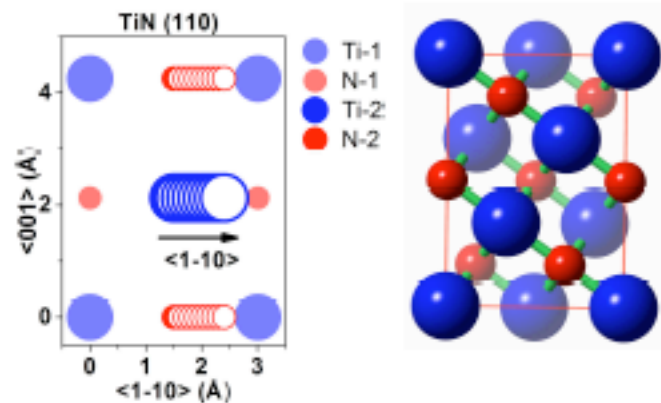
- The shear strengths of Al are lower in the $\langle 11\bar{2}\rangle$ shear direction compared to the $\langle 1\bar{1}0\rangle$ shear direction
- When Al is sheared in the $\langle 11\bar{2}\rangle$ direction, the upper layer of atoms move symmetrically with respect to the lower layer, while movement of atoms due to shearing along the $\langle 1\bar{1}0\rangle$ direction is hindered

* S. Ogata, et al., Science 298, 807 (2002).

** M. Jahnatek, et al., Phys. Rev. B 79, 224103 (2009).

Ideal Shear Strength of TiN

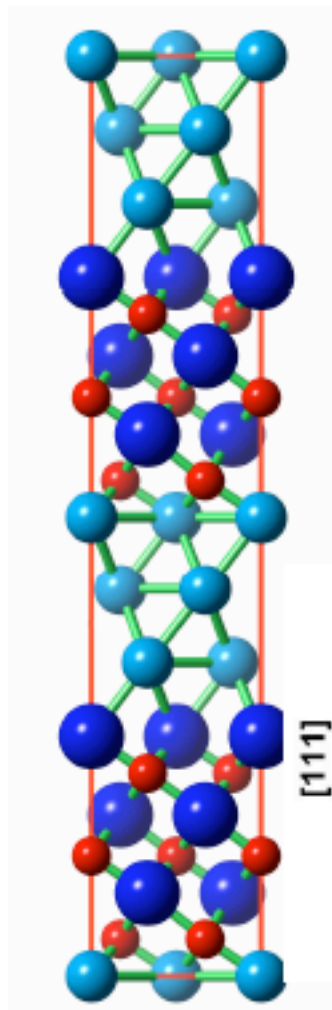
Shear systems	Simple shear		Pure shear		
	Shear strength (GPa)	Shear strain	Shear strength (GPa)	Shear strain	% Volume Increase
$\{111\}\langle 11\cdot2\rangle$	45.5	0.38	29.0	0.21	3.8
$\{111\}\langle 1\cdot10\rangle$	121.0	0.73	35.3	0.33	10.8
$\{001\}\langle 100\rangle$	51.2	0.42	35.5	0.28	1.6
$\{001\}\langle 110\rangle$	39.4	0.33	32.7	0.28	1.3
$\{110\}\langle 1\cdot10\rangle$	151.6	0.60	29.0 (31.0*)	0.20	6.0
$\{110\}\langle 001\rangle$	65.6	0.47	56.4	0.47	1.5



* S.-H. Jhi, et al., Phys. Rev. Lett. 87, 075503 (2001).

- Various shearing planes and directions have similar shear strength, hence various possible slip systems.
- For comparison, MgO prefers slip system $\langle 110\rangle\{110\}$; AgCl has “pencil” slip of $\langle 110\rangle$. Pencil slip is possible if slip can occur readily on $\{111\}$ planes or a combination of $\{100\}$, $\{110\}$, or $\{111\}$ planes.

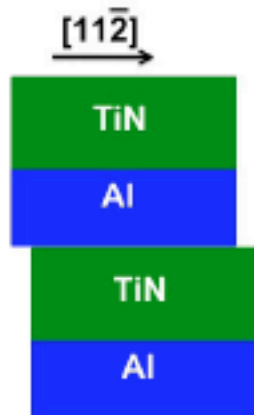
Ideal shear strength of Al/TiN interface along $\langle 11\bar{2} \rangle$



	Interface 1		Interface 2	
	Shear strength (GPa)	Shear strain	Shear strength (GPa)	Shear strain
Al/N	19.1	0.39	26.4	0.49
Al/Ti	3.3	0.18	3.2	0.18

Interface 1: Equal and opposite biaxial stress in Al and TiN layers

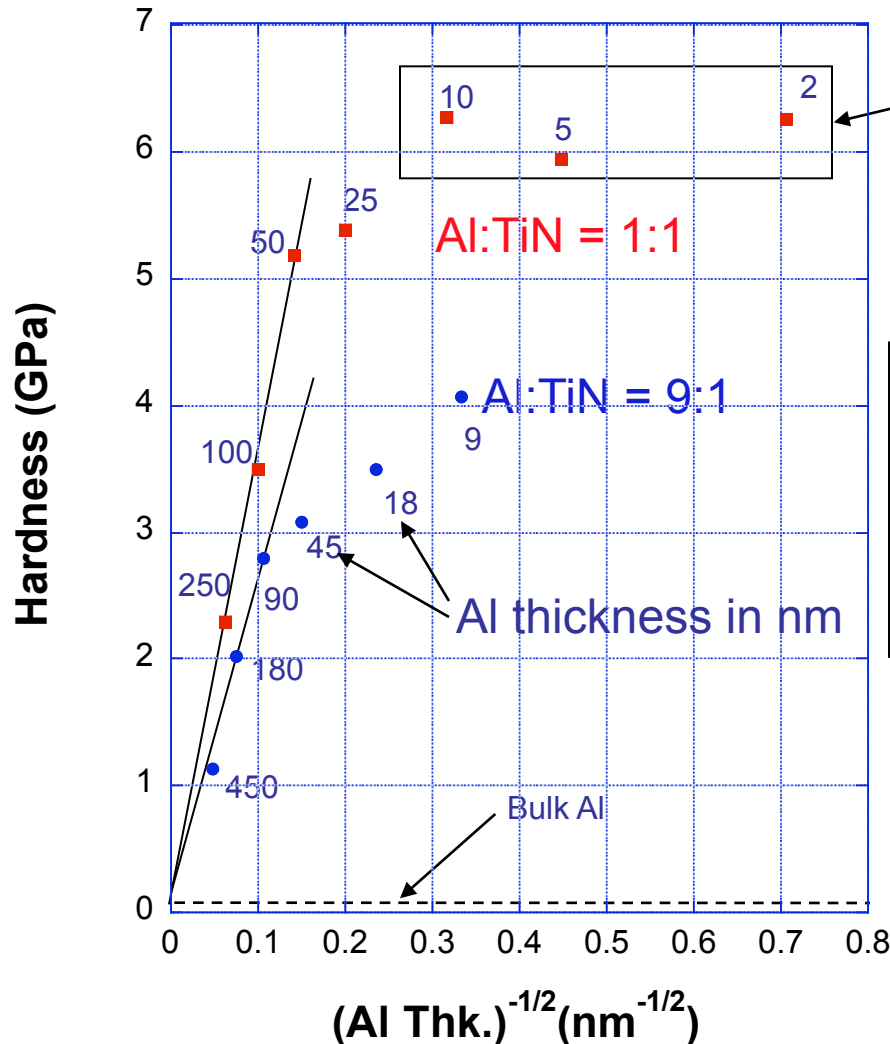
Interface 2: Al lattice parameter stretched to match TiN layers



- The ideal shear strength of Al/TiN interfacial region depends strongly on the interface chemistry
- Ideal shear strength of the interface is on the order of those of pure TiN and pure Al for N and Ti interfacial terminations

Effects of layer thickness and volume fraction on hardness of Al/TiN multilayers

Hall-Petch curve based on Al layer thickness



Deviation from Hall-Petch -
change in mechanism

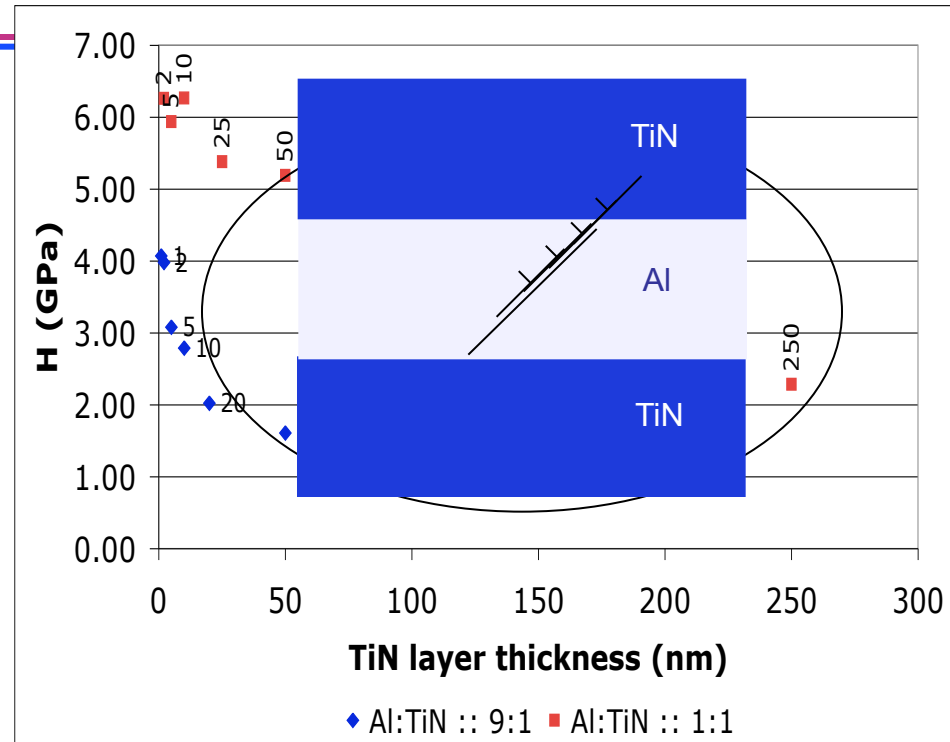
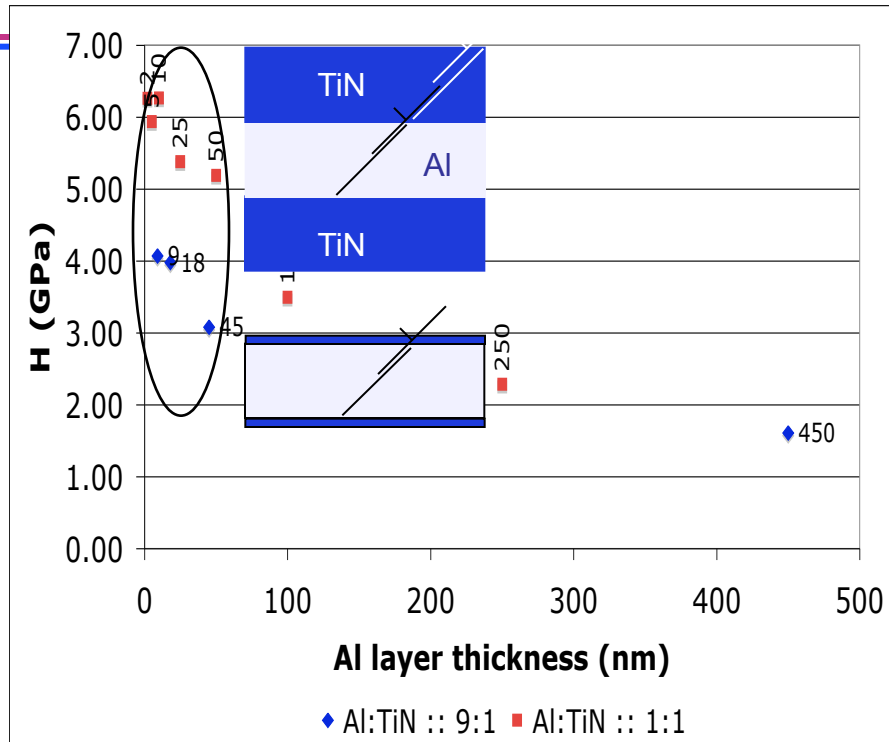
Hall-Petch slopes scale with
composite moduli

At large layer thickness, dislocation
pile-up in Al is the key unit mechanism
(Hall-Petch effect);

=> TiN volume fraction less important.

At small thickness, deformation by
single dislocation crossing of
individual layers - co-deformation of
Al and TiN occurs - V_f of TiN more
important.

Hardness vs Al and TiN layer thickness

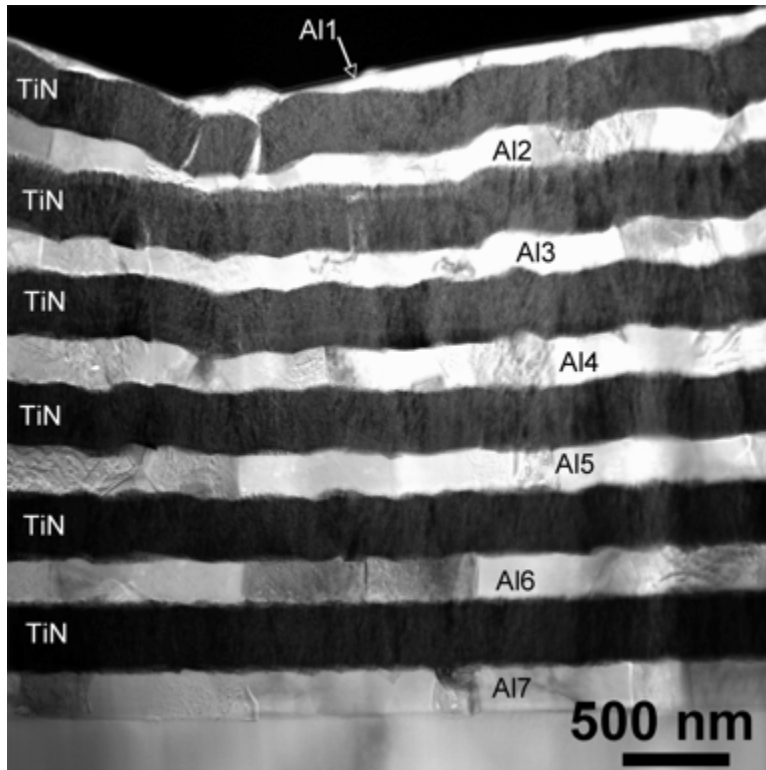


V_f of TiN has greater effect on hardness at smaller Al layer thickness.

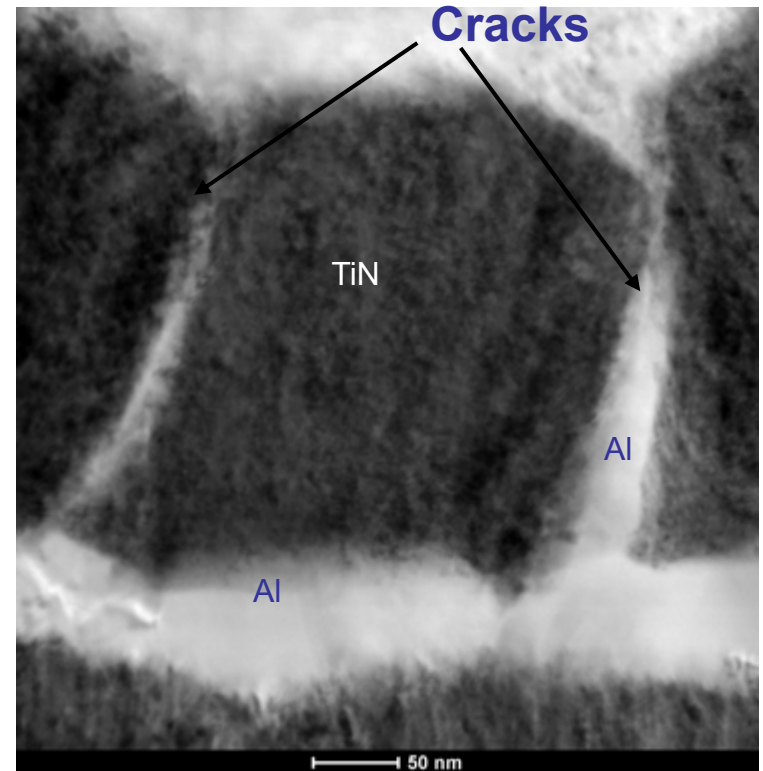
At small thickness, deformation by single dislocation crossing of individual layers - co-deformation of Al and TiN occurs - V_f of TiN more important

At large layer thickness, deformation is confined to Al and the hardness increase is due to dislocation pile-up mechanism (Hall-Petch effect).

Indent in Al-250nm - TiN-250nm sample

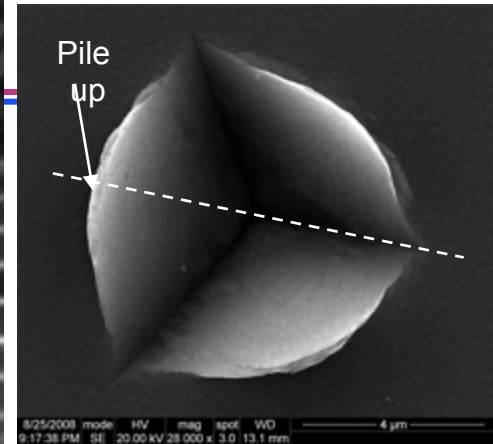
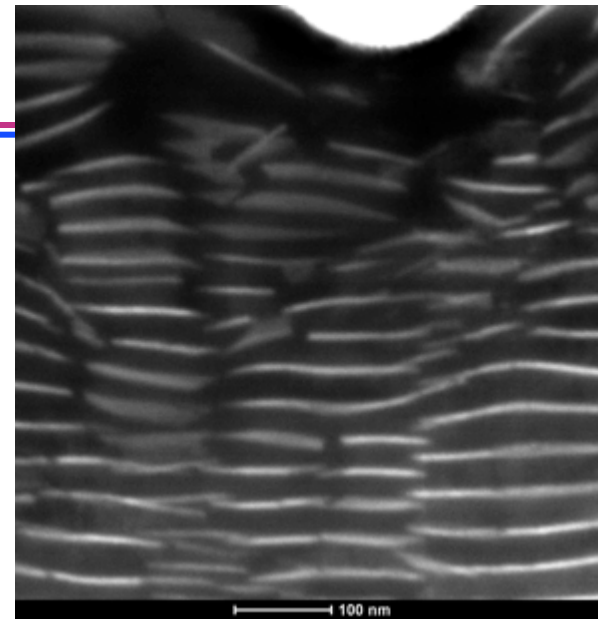
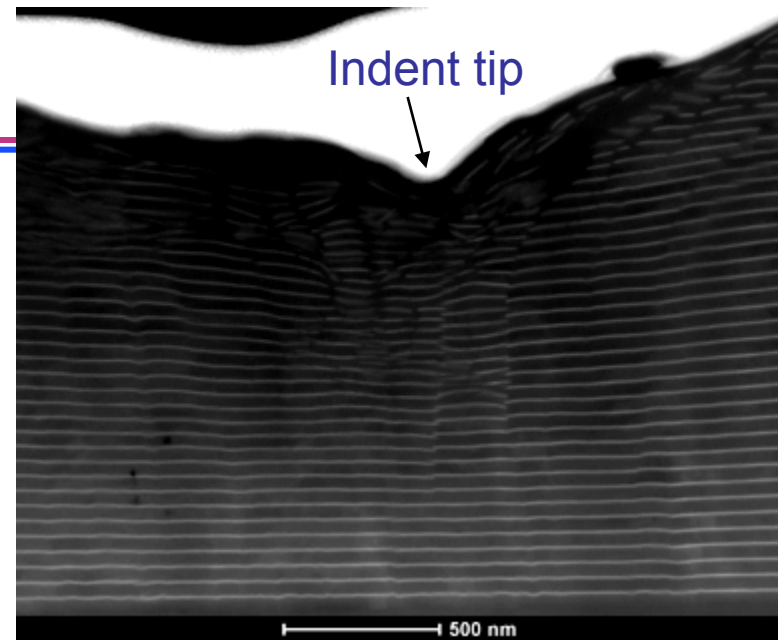


Deformation confined to Al layers, decreasing towards the bottom



Al extruded into the cracks in the TiN layers

Indent in Al-45nm - TiN-5nm



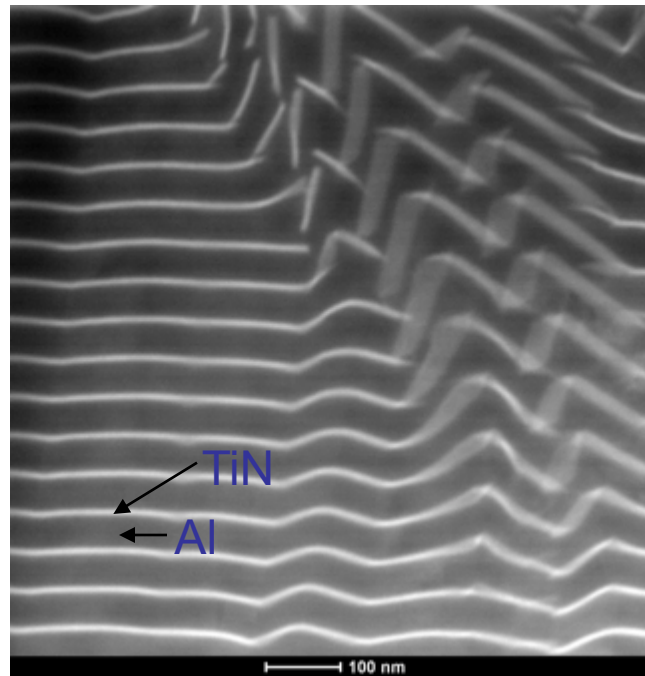
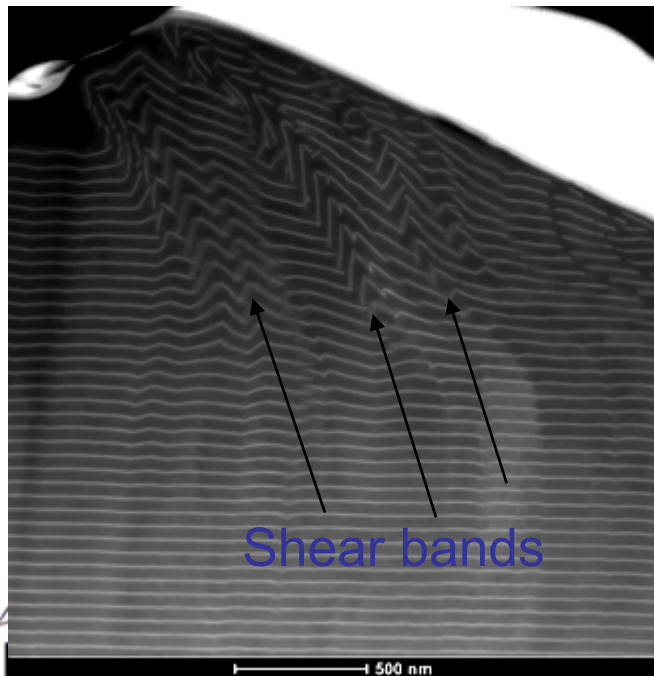
TiN layers break
at

column
boundaries

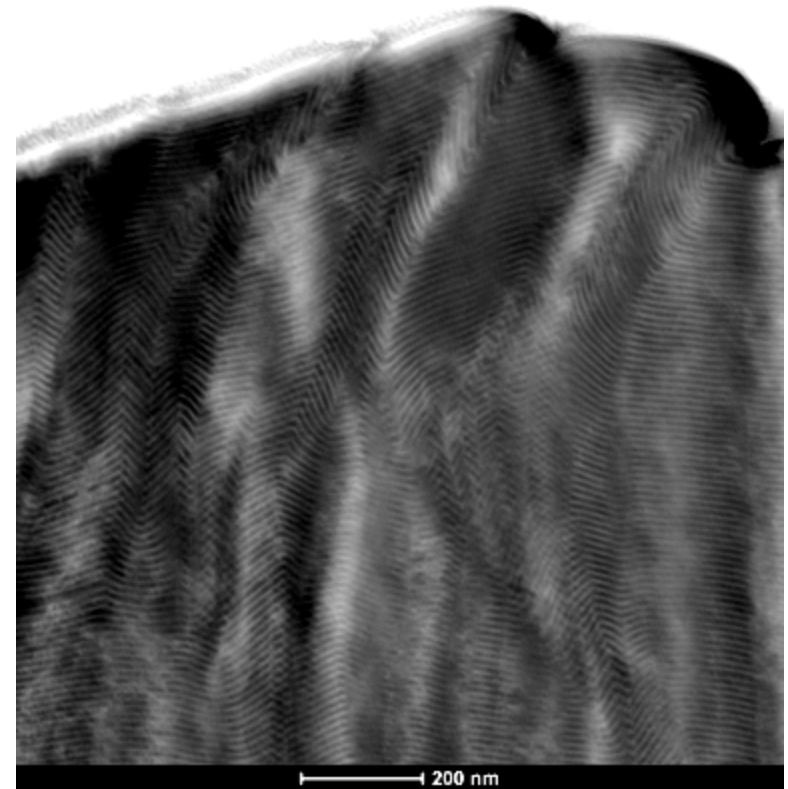
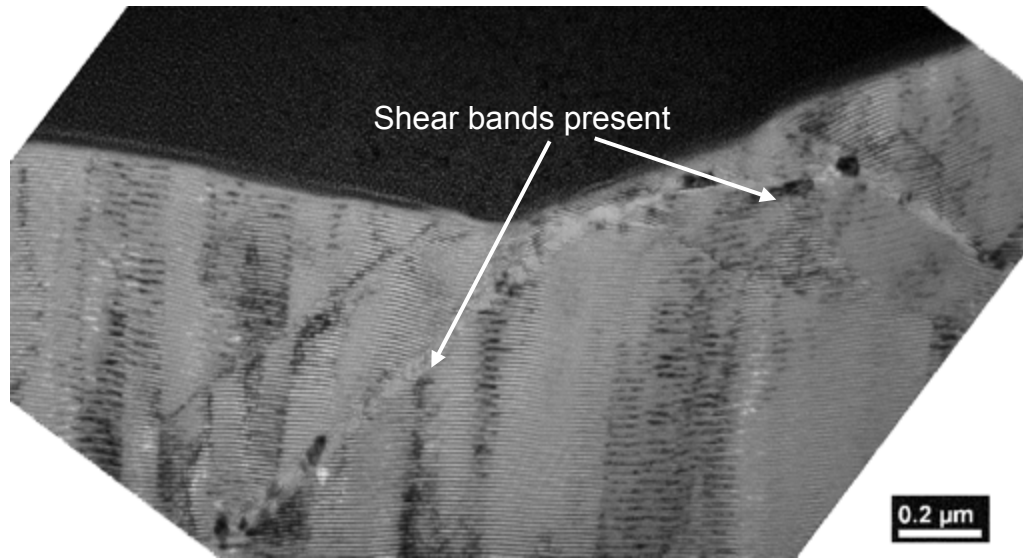
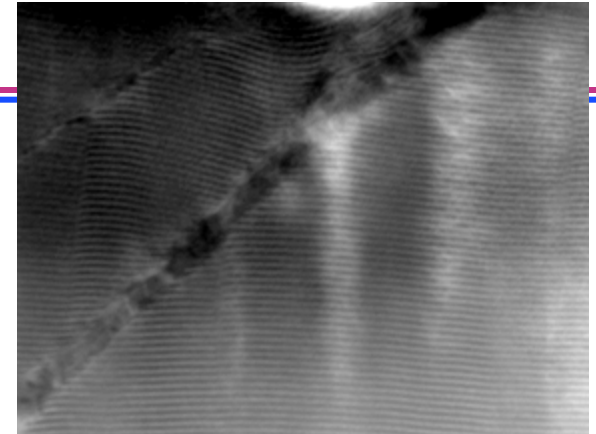
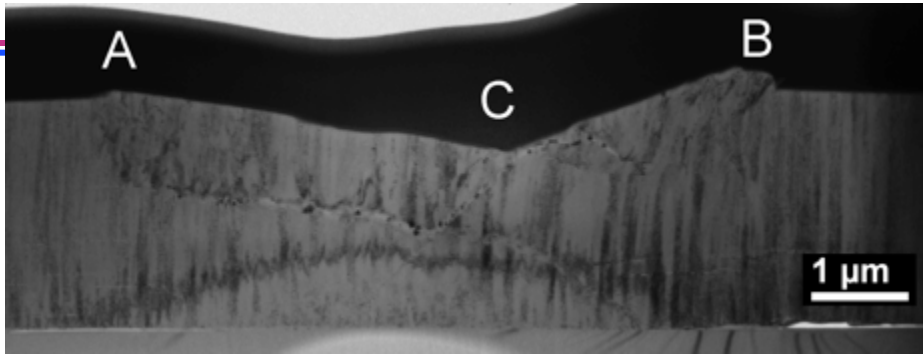
and

shear bands

HAADF STEM
images



Indent Al-9nm - TiN-1nm



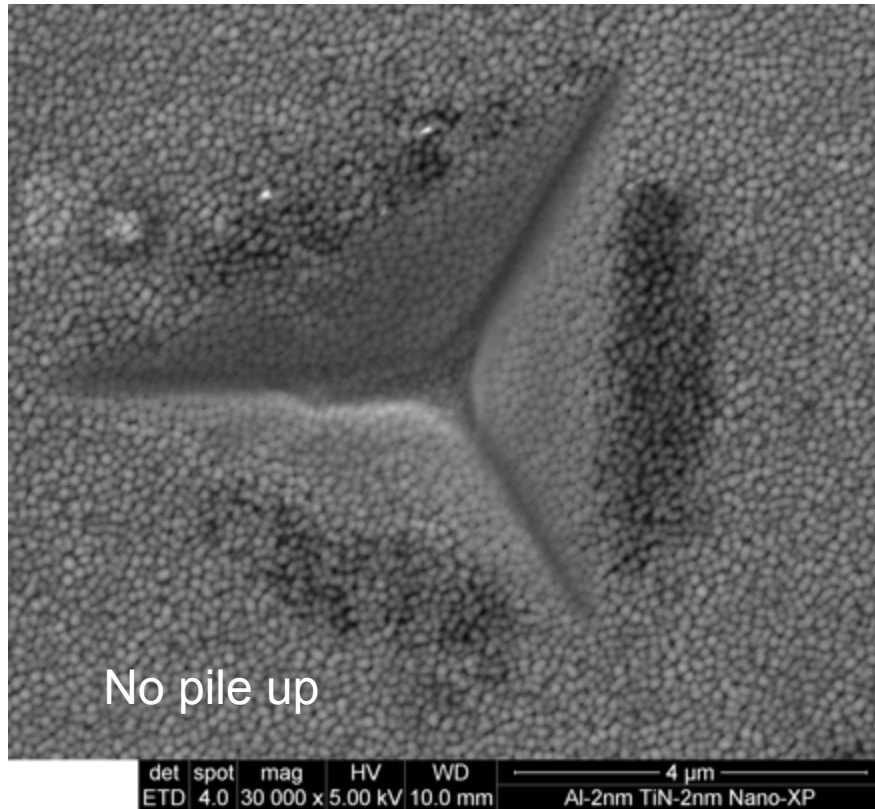
Shear bands

Breakage of TiN layers

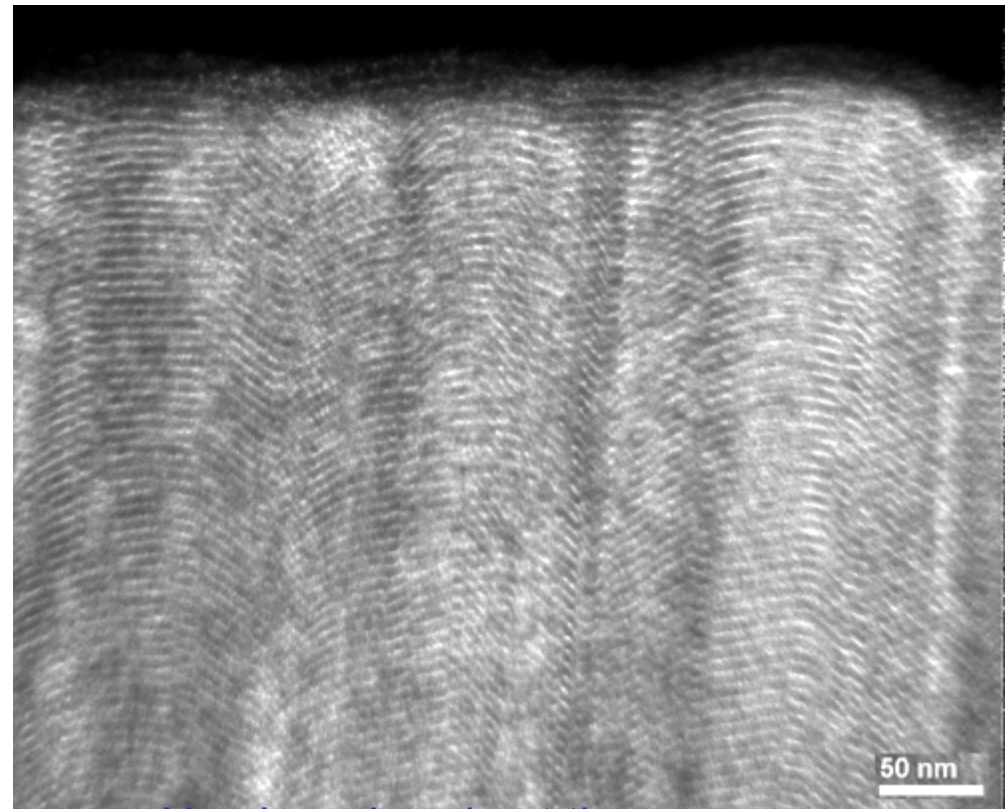
Co-deformation of nanoscale ceramic with nanoscale metal

D. Bhattacharyya, N. A., Mara, P. Dickerson, R. G. Hoagland, and A. Misra, *Philosophical Magazine*, **90**: 13, 1711 — 1724 (2010).

Plan view SEM

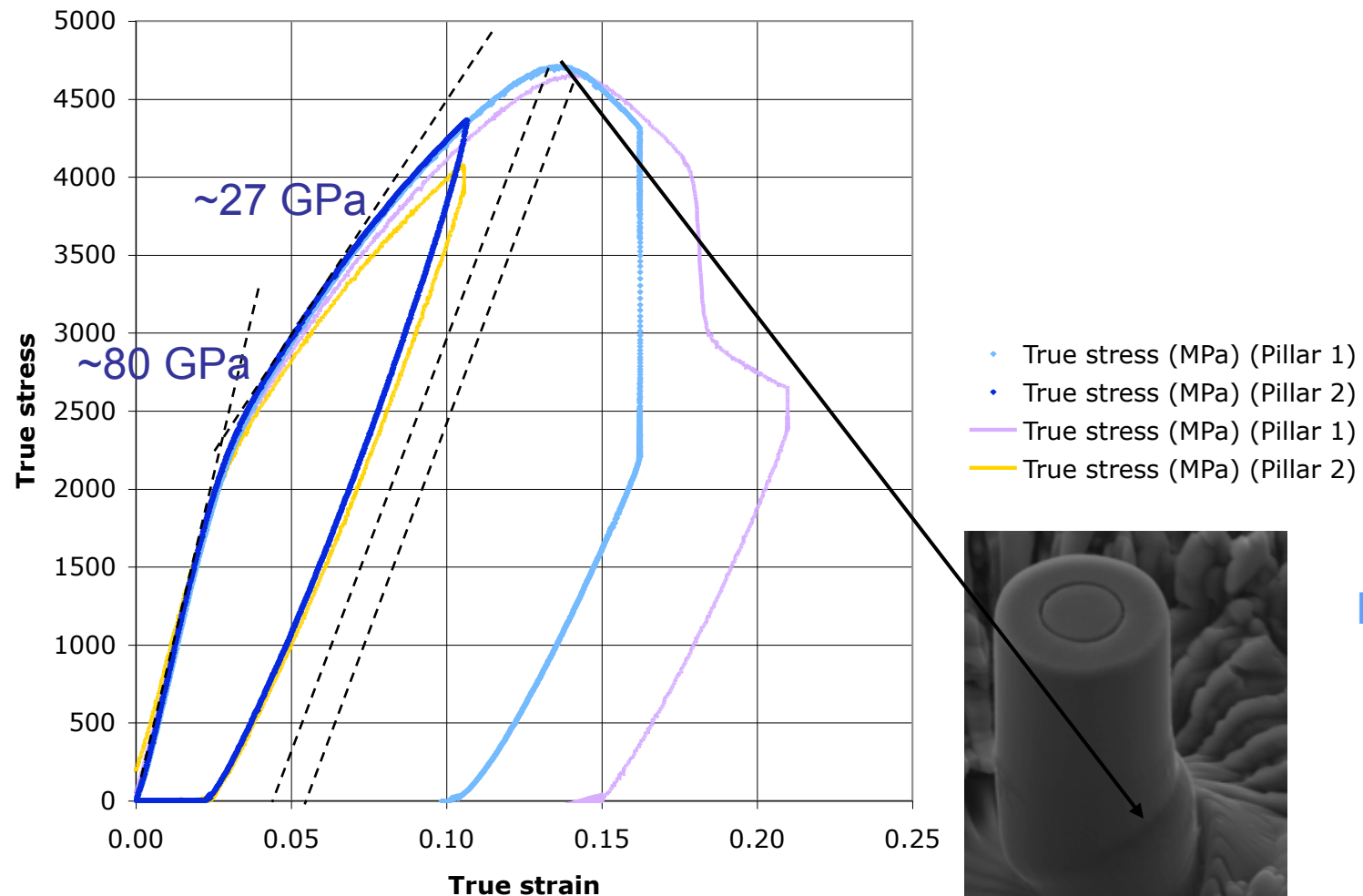


Cross-section TEM

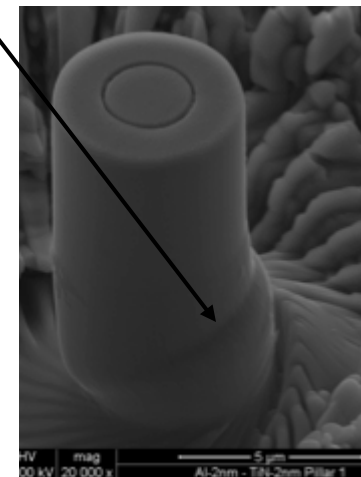


Pillar compression results - Al-2nm - TiN-2nm

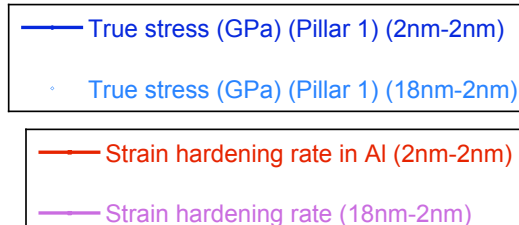
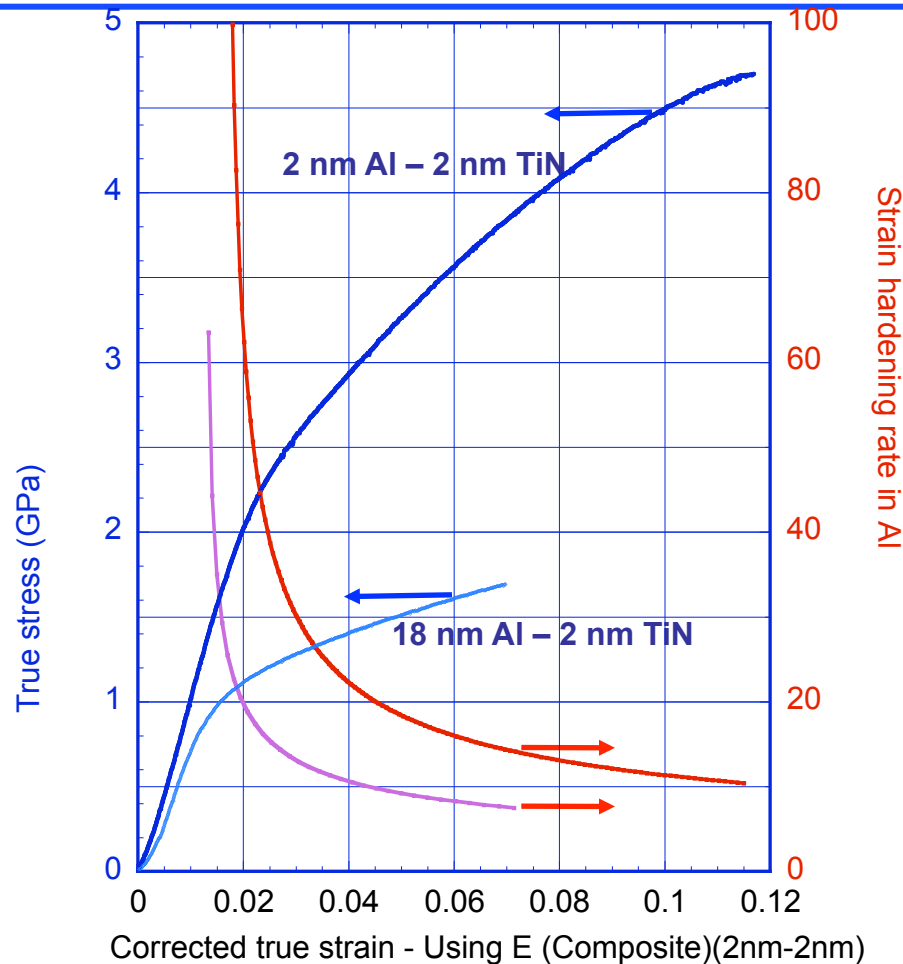
Peak strength ~ 4.7 GPa, retained plastic strain $\sim 5-6\%$



Pillar 1



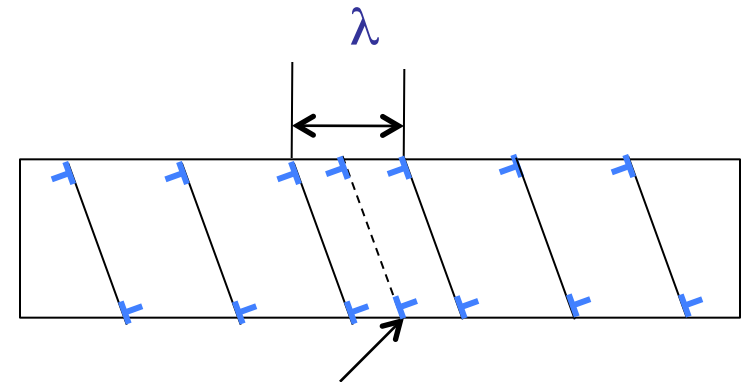
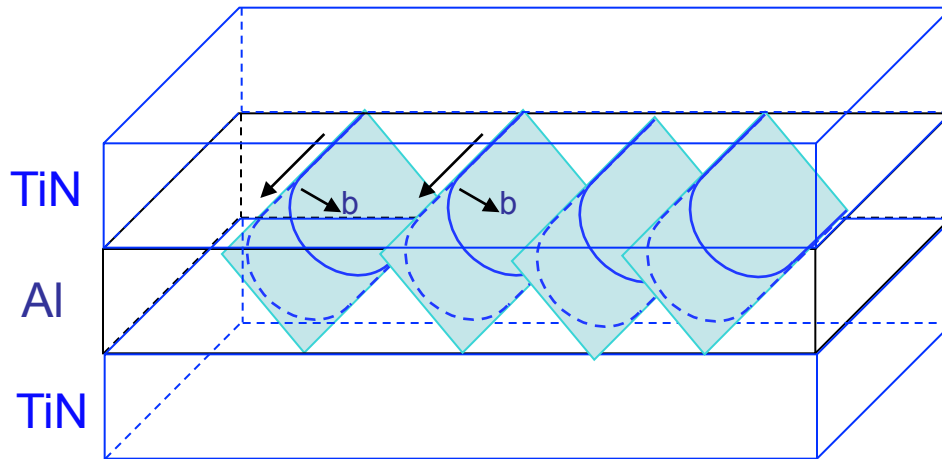
Work hardening rate in nanolayered Al-TiN is very high and increases with decreasing layer thickness



What is the strain hardening limit due to dislocation interactions in confined nanometer scale metal films?

W.D. Nix, *Mathematics and Mechanics of Solids*, **14**, 207 (2009):

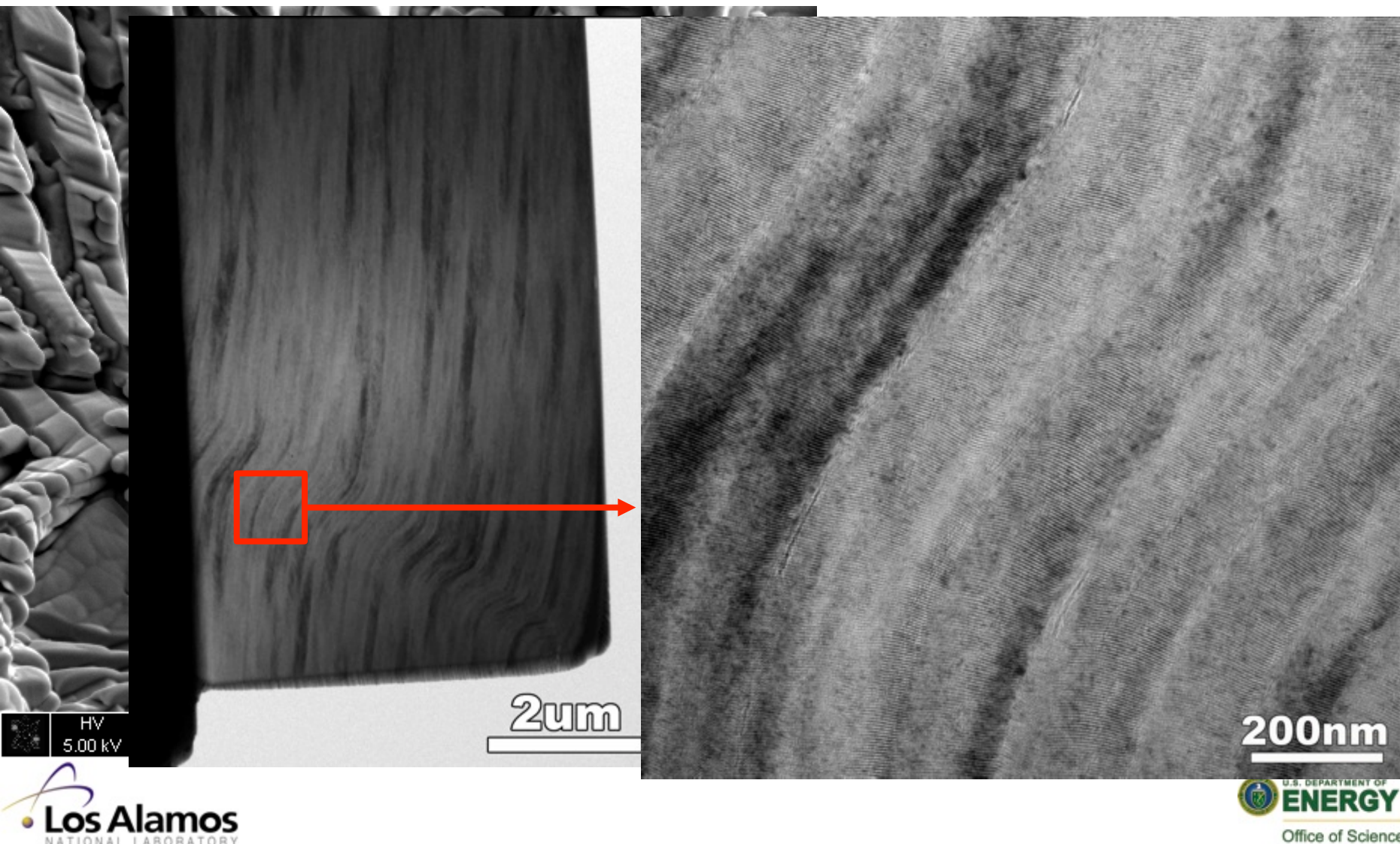
An edge dislocation climb model was used to show that strain hardening rate in thin films can approach $E/2$.



TEM observations have confirmed such confined layer slip:

- G. Dehm, *Prog. Mat. Sci.* (2009)
- N. Li, *et al.*, *Microscopy & Microanalysis*, (2012), in press.
- K. Hattar, *et al.*, *Journal of Engineering Materials and Technology*, (2012).

Deformability may be limited by cracking along column boundaries



Indentation Fracture Studies of Al-TiN

- Indentation fracture with cube corner to drive radial fracture.
- Load range: 1 μN to 2 N
- Indentation strain rate: 5 orders of magnitude
- Constant indentation strain rate:

$$\dot{\epsilon} = \left(\frac{\dot{h}}{h} \right) = \frac{1}{2} \left(\frac{\dot{P}}{P} \right)$$

Lucas, Oliver, Pharr, Loubet, *MRS Proc.* **436** (1997) 233.

E.g., for a maximum load of 500 mN:

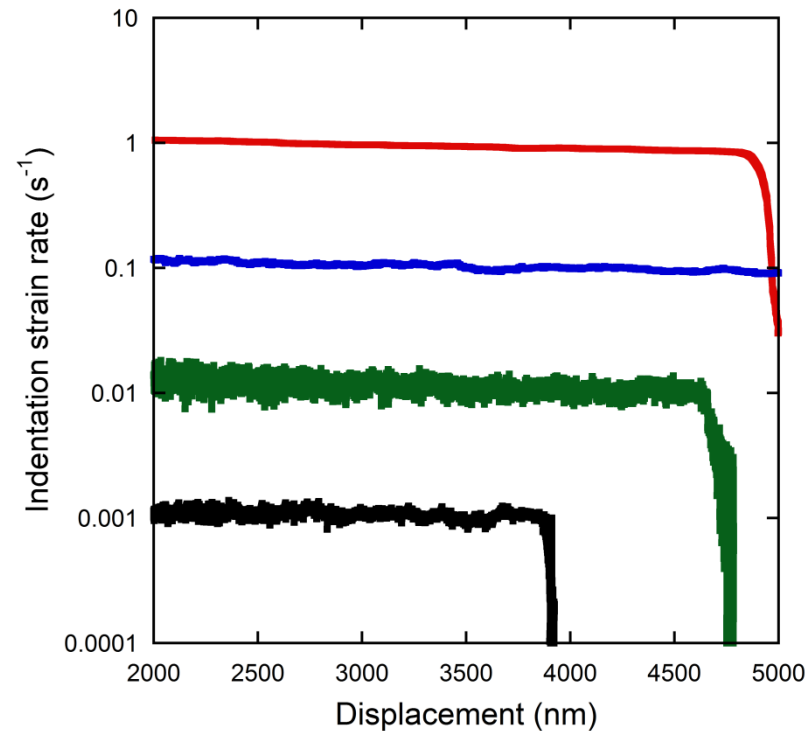
$\dot{\epsilon} = 10$, loading 0.3 s

$\dot{\epsilon} = 1.0$, loading 3 s

$\dot{\epsilon} = 0.1$, loading 30 s

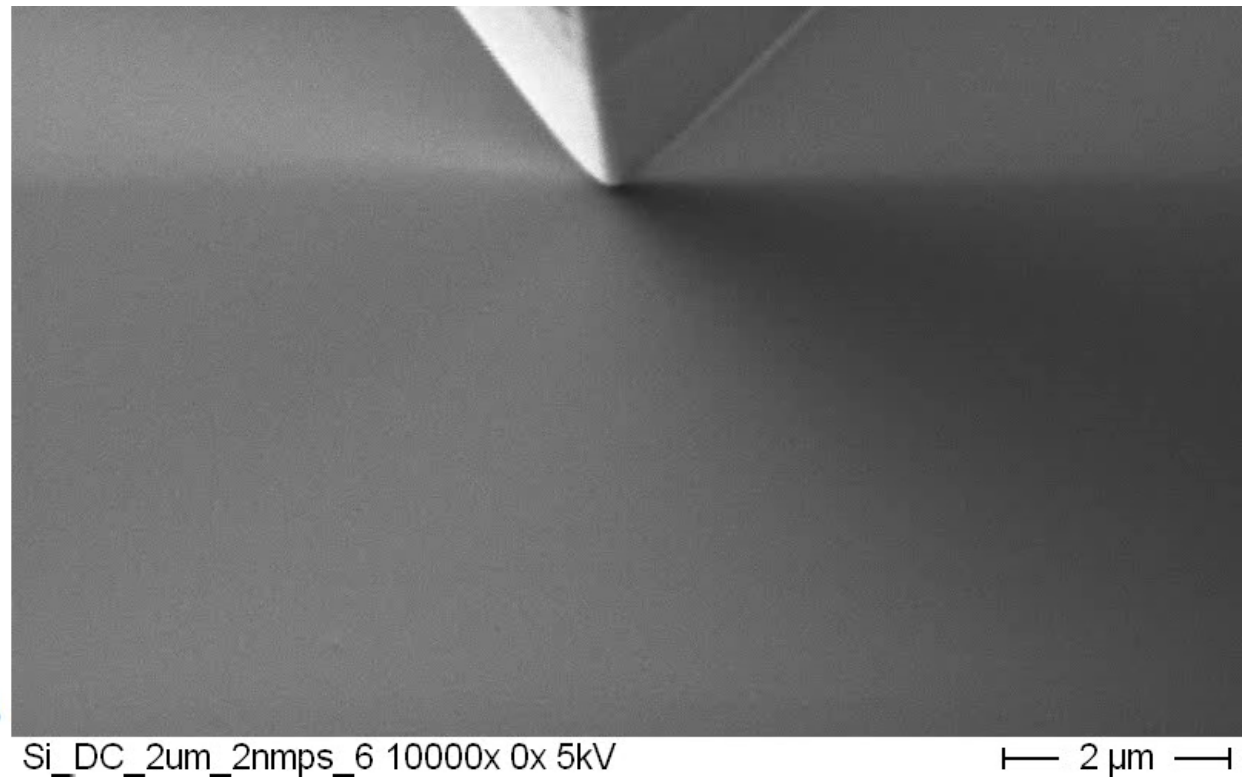
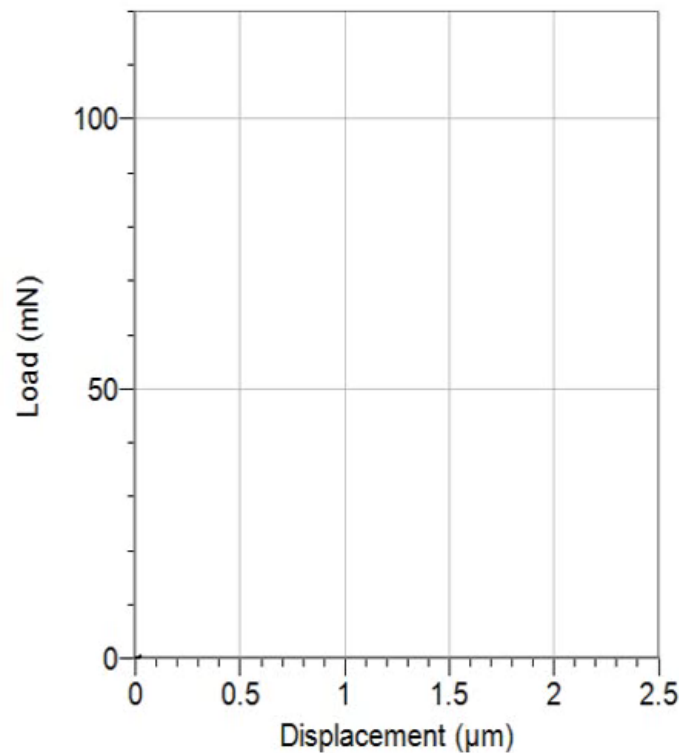
$\dot{\epsilon} = 0.01$, loading 300 s

$\dot{\epsilon} = 0.001$, loading 3000 s



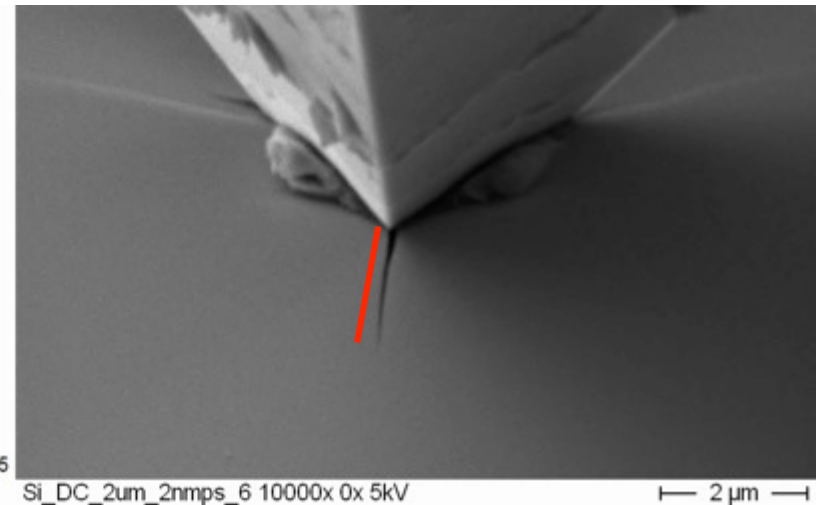
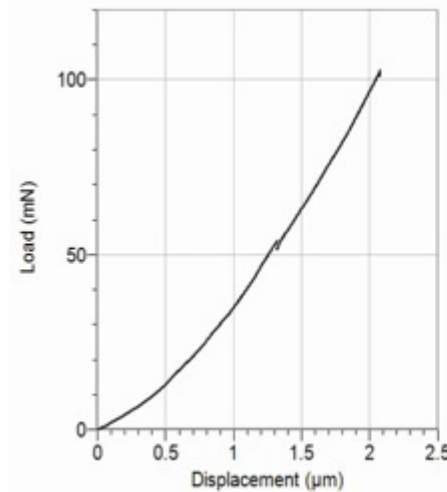
Data from indentation of Al-TiN (5nm-5nm)

Indentation into silicon: example of traditionally brittle behavior at the microscale

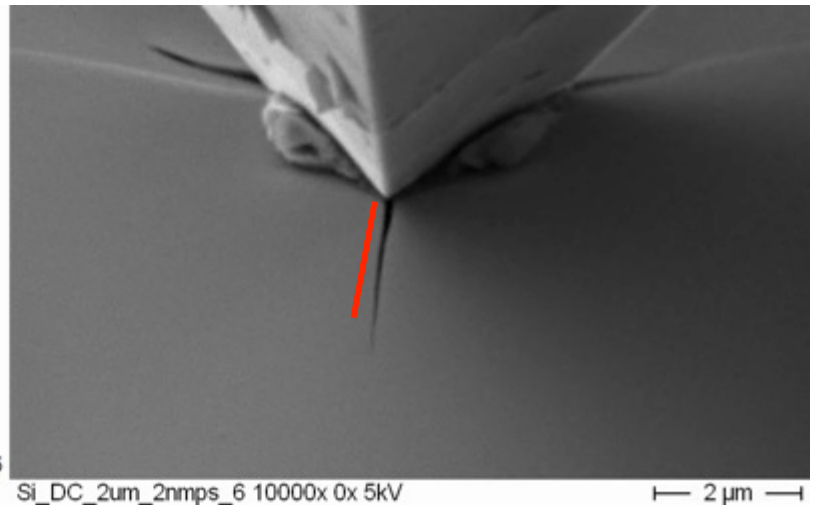
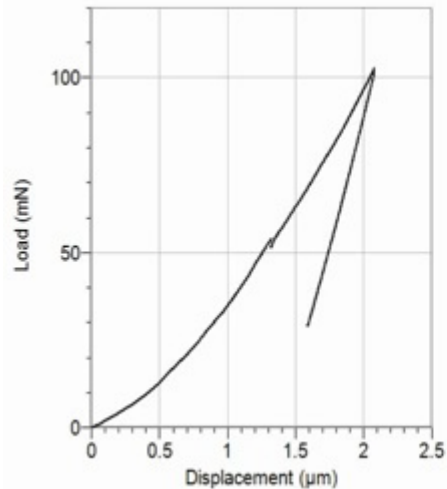


Crack growth during unloading in silicon

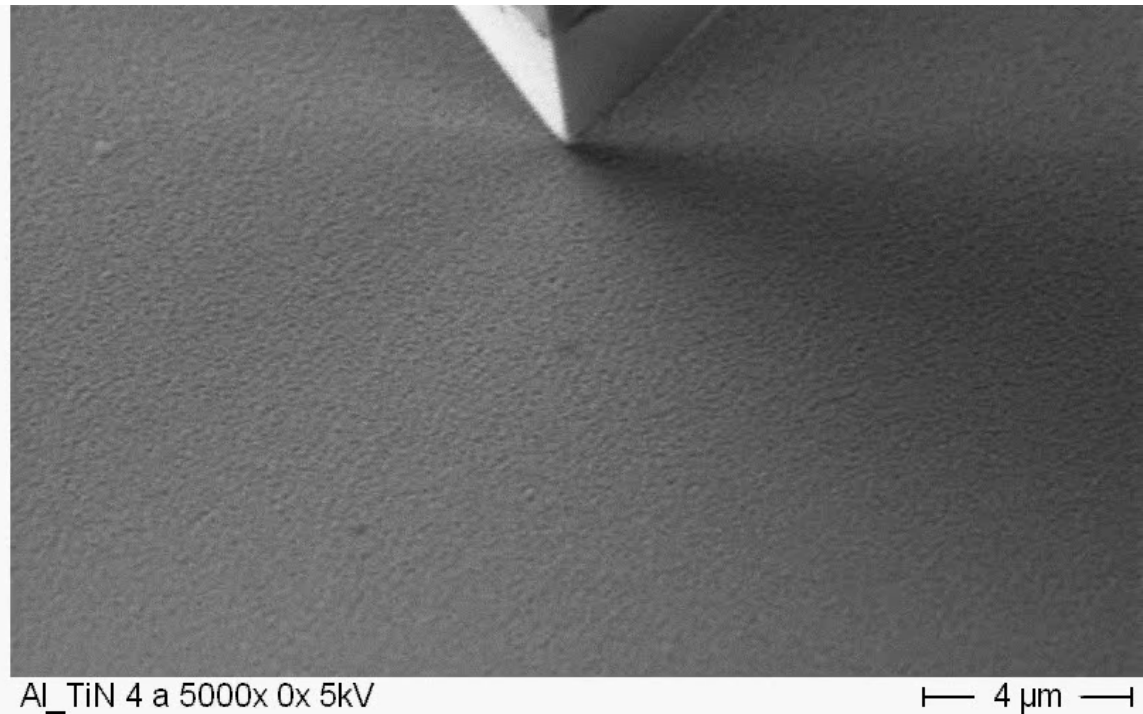
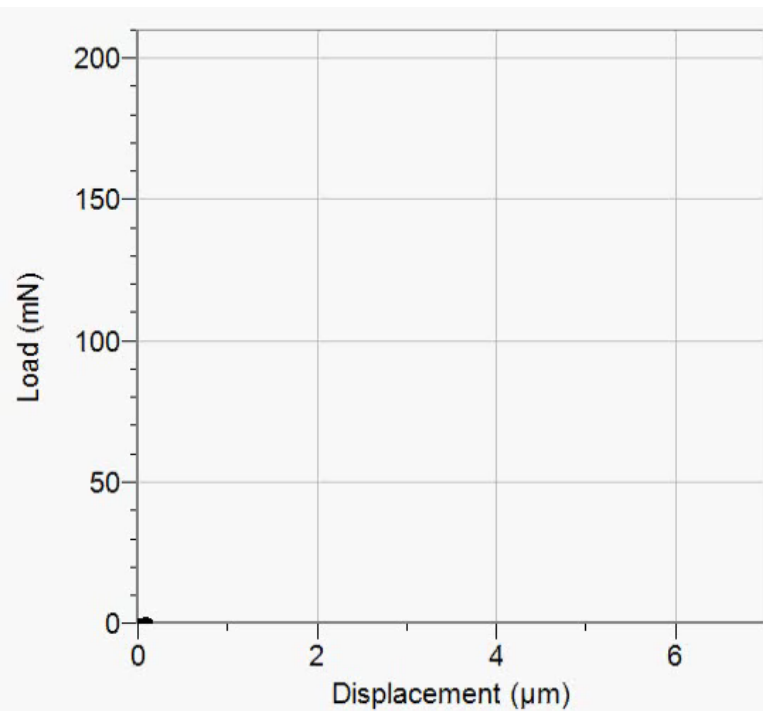
Frame 224:
Load: 102 mN
At maximum load.



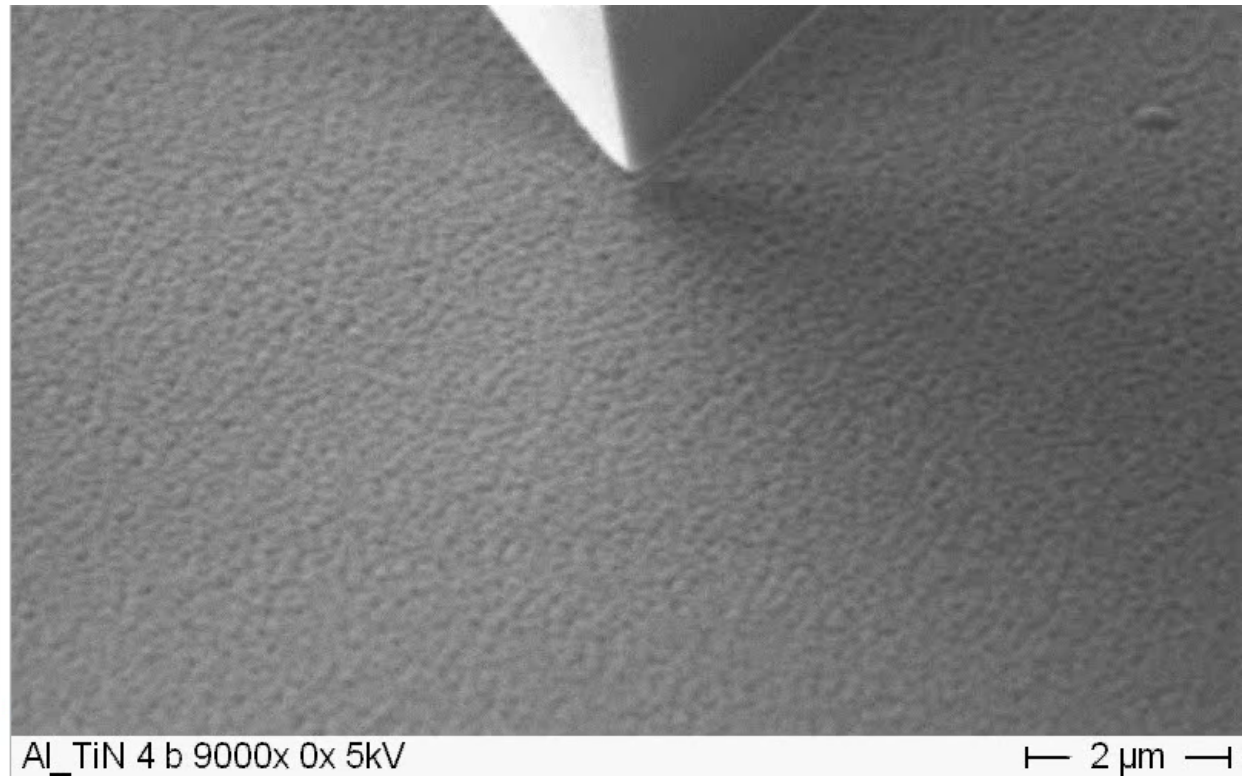
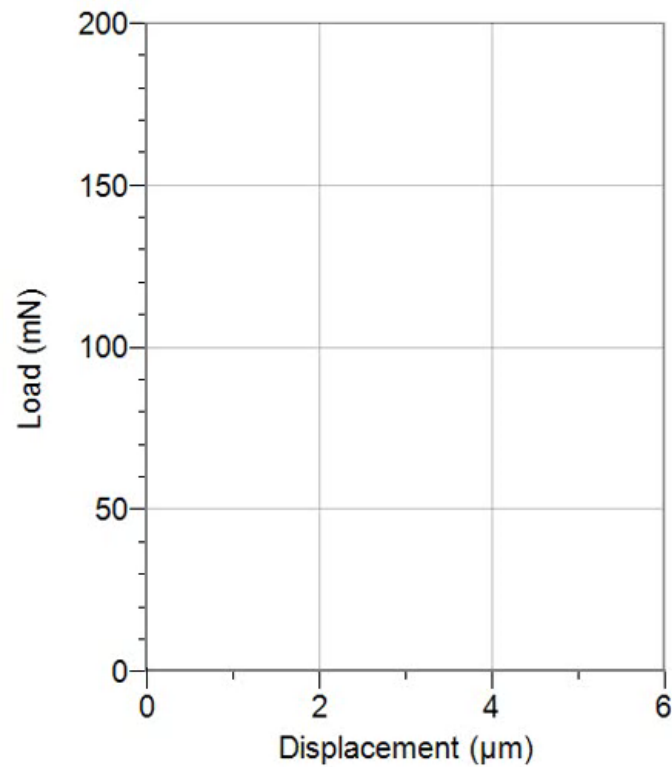
Frame 290:
Load: 28 mN
During unloading.



Indentation of Al-TiN (9nm-1nm), Indent A $\dot{\epsilon} \approx 0.001$

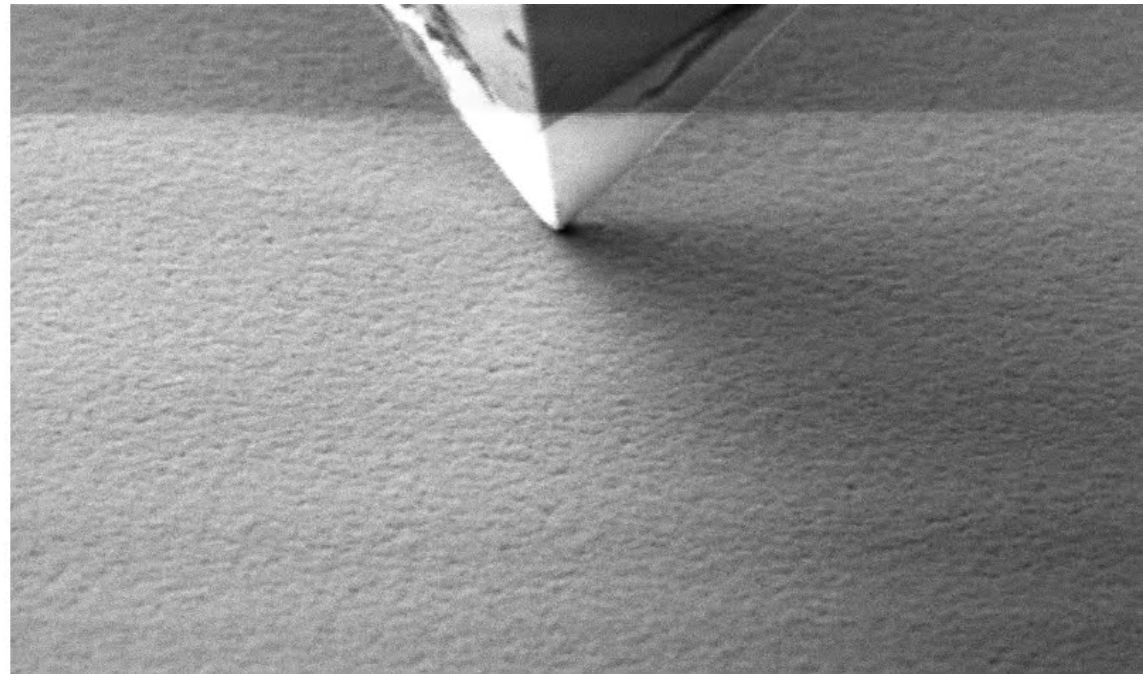
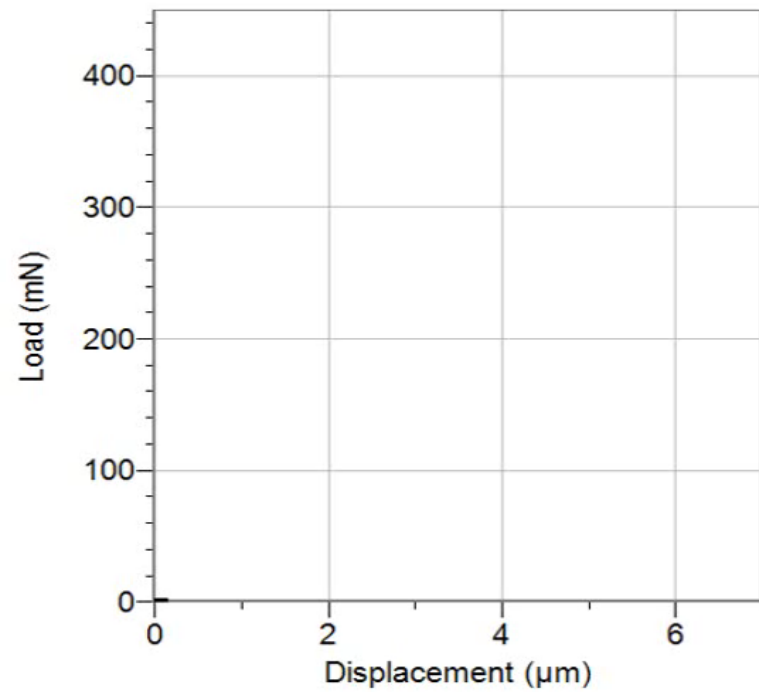


Al-TiN (9nm-1nm), Indent B $\dot{\epsilon} \approx 0.0005$



Al-TiN (5nm-5nm)

$$\dot{\varepsilon} \approx 0.005$$

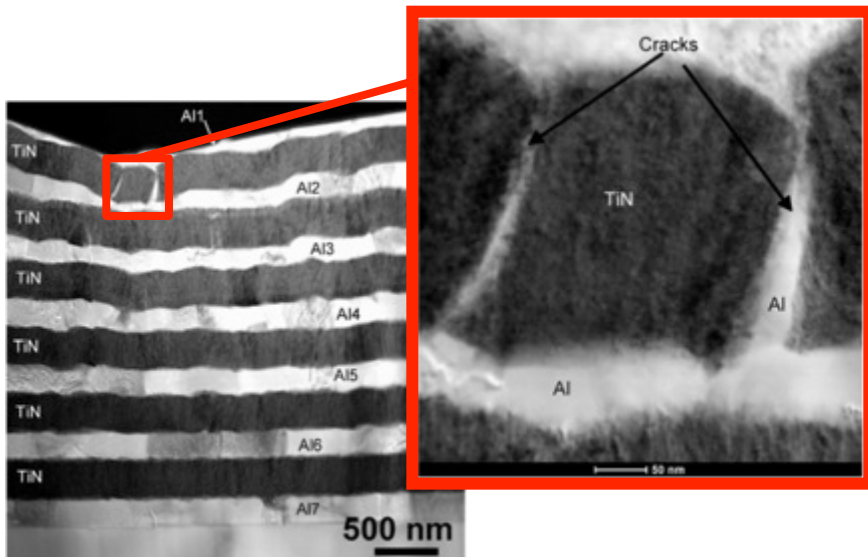


Al_TiN 3 b 5000x 0x 5kV

4 μm

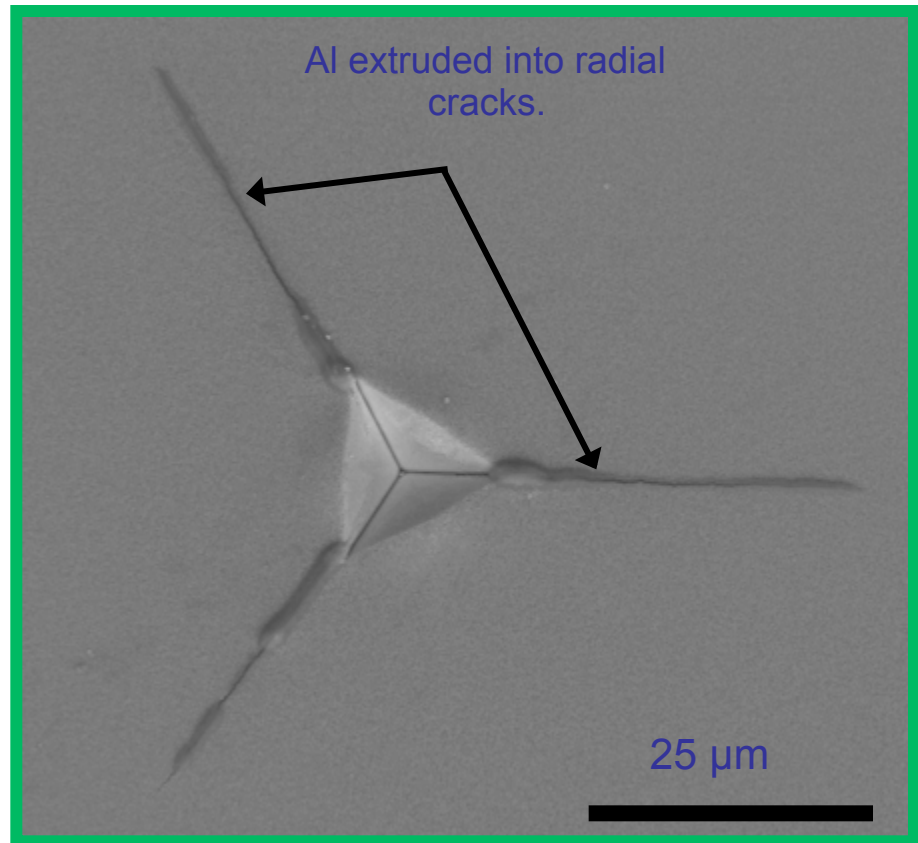
Toughening mechanism in Al-TiN: Flow of Al blunts crack tips

Al-TiN (250nm-250nm) indent where
Al flowed into cracks.



Bhattacharyya, et al. *Phil. Mag.* **90**, 13 (2010) 1711

Al-TiN (5nm-5nm) indent to 1N followed
by reloading.



Summary: *Metal-Ceramic Multilayer Deformation*

- In nanolayered Al/TiN, Al layers grow in a twin orientation with the underlying TiN/Al layers favored by N-terminated TiN layers.
- The shear strength of Al/TiN interface varies significantly depending on whether the interface is Ti or N terminated.
- 2 nm Al - 2 TiN multilayers exhibit unusual mechanical properties as revealed by compression testing:
 - High maximum flow strength of 4.5 GPa, which is significantly higher than hardness (6 GPa) divided by a factor of 3.
 - Extraordinarily high strain hardening rates in Al nanolayers (16-35 GPa, $\approx E/2$ to $E/4$).
 - Co-deformability of the TiN nanolayers with Al (confirmed by TEM on nanoindents) to plastic strains in excess of 5%.

Summary: *Metal-Ceramic Indentation Fracture*

- No radial crack growth during unloading.**
- Shear bands form at expense of radial cracks. At low strain rates, no radial cracks are observed.**
- Flow of Al into the cracks in TiN may be a toughening mechanism.**
- Co-deformation of Al and TiN delays the crack initiation to higher load.**

Outline

Motivation: Thin film multilayer as model geometry for studying defect interactions at interfaces as a function of length scale and interface structures

Mechanical Behavior: Dislocation and crack interactions with metal-ceramic interfaces

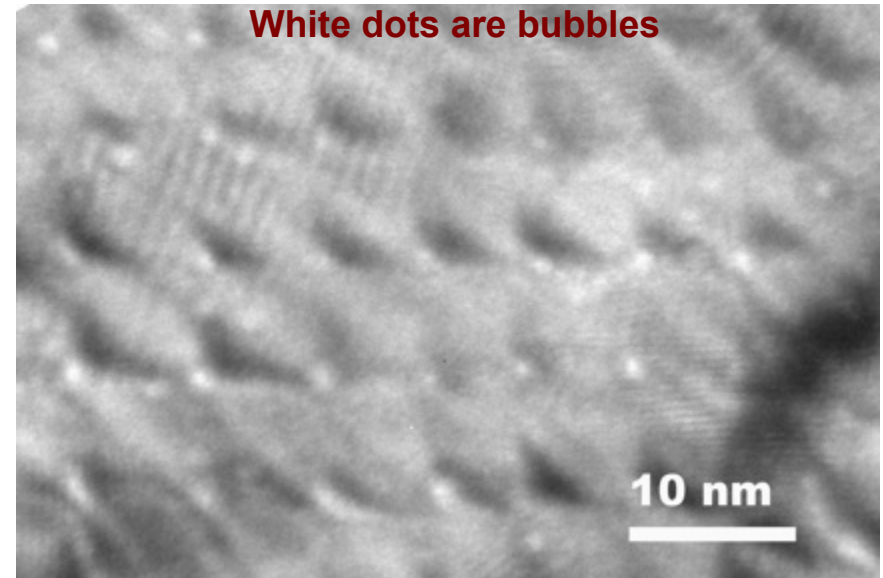
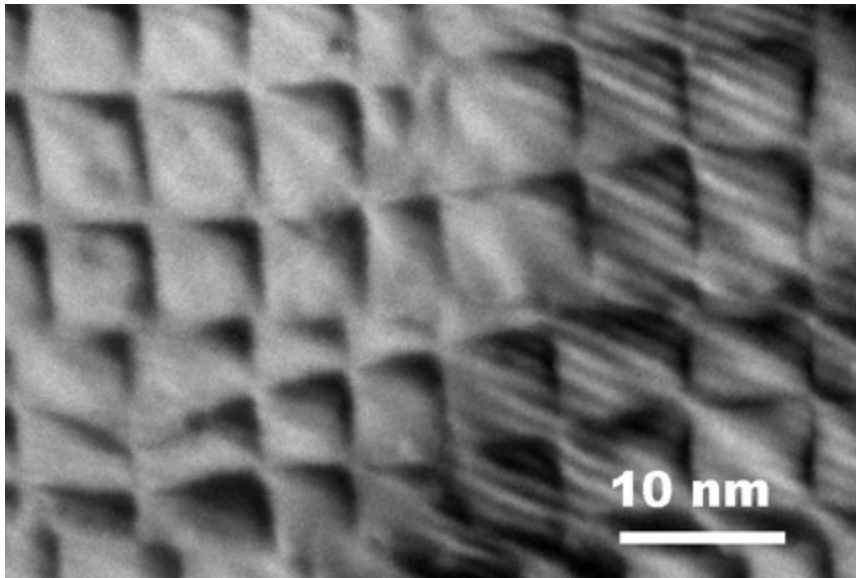
 **Radiation Damage**: Point defect interactions with metal-ceramic interfaces
Example highlighted: helium trapping at interfaces

Helium bubbles preferentially nucleate at misfit dislocation intersections at interfaces

Pristine

2° [100] Au-Au twist boundary

He implanted



- Misfit dislocation intersections (MDI's) provide a template to stabilize nano-meter scale He bubbles at interfaces.

Hypothesis: Amount of helium trapped depends on MDI spacing which can be tailored via lattice misfit (interphase boundaries) or misorientation (grain boundaries)

Zengfeng Di, *et al.*, Phys. Rev. B, 84, 052101 (2011)

Lane, Goodhew, Phil. Mag (1983); B.N. Singh, *et al.*, JNM (1984).

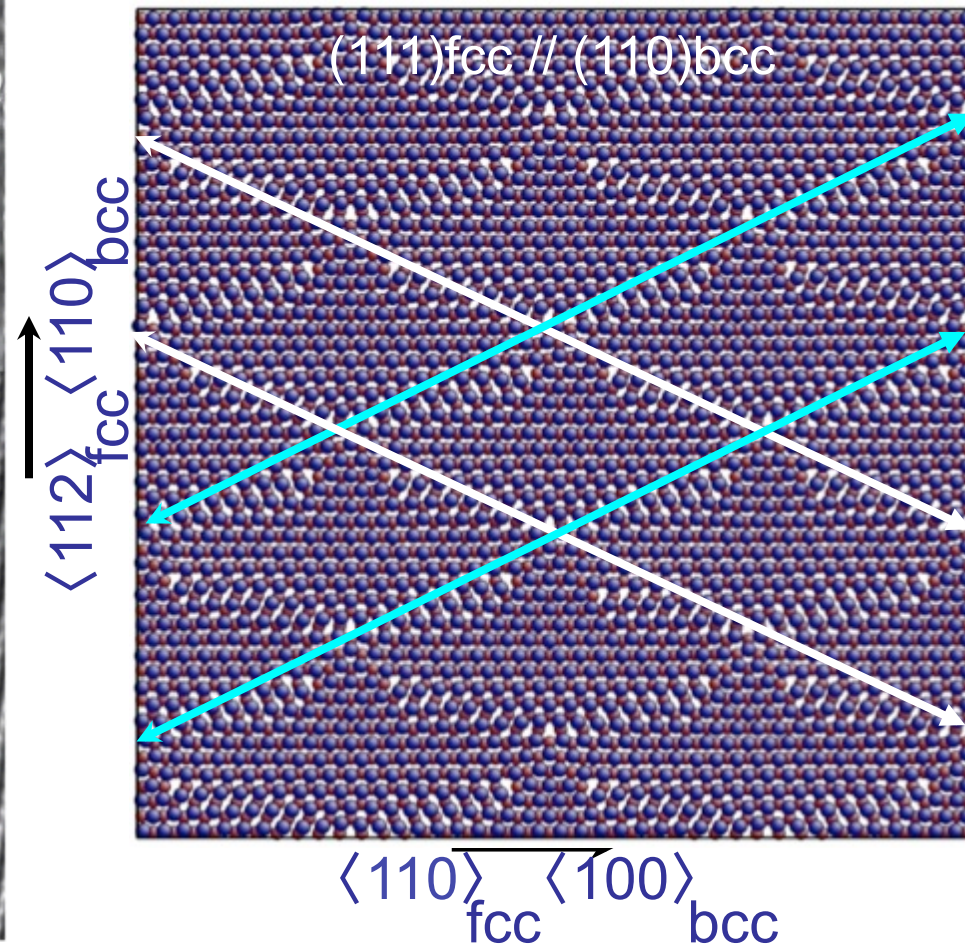
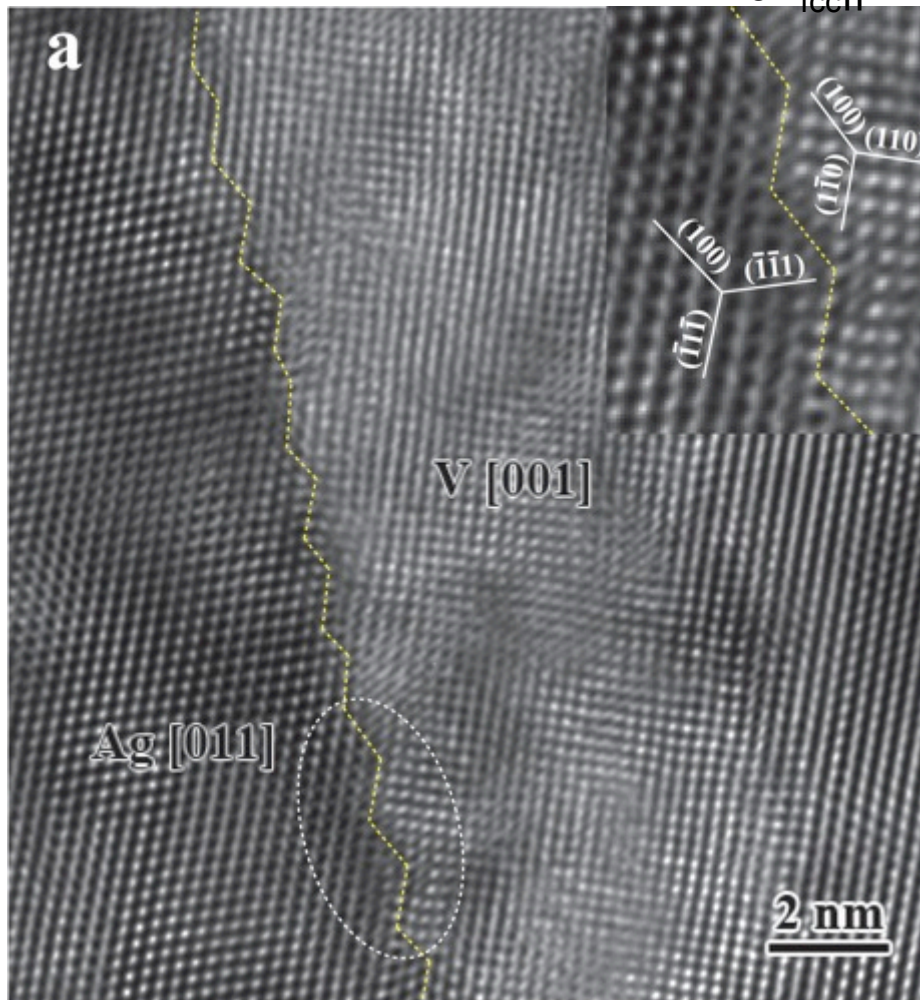
Misfit dislocation intersections are the preferred sites for helium trapping at interphase boundaries

Example from Ag-V

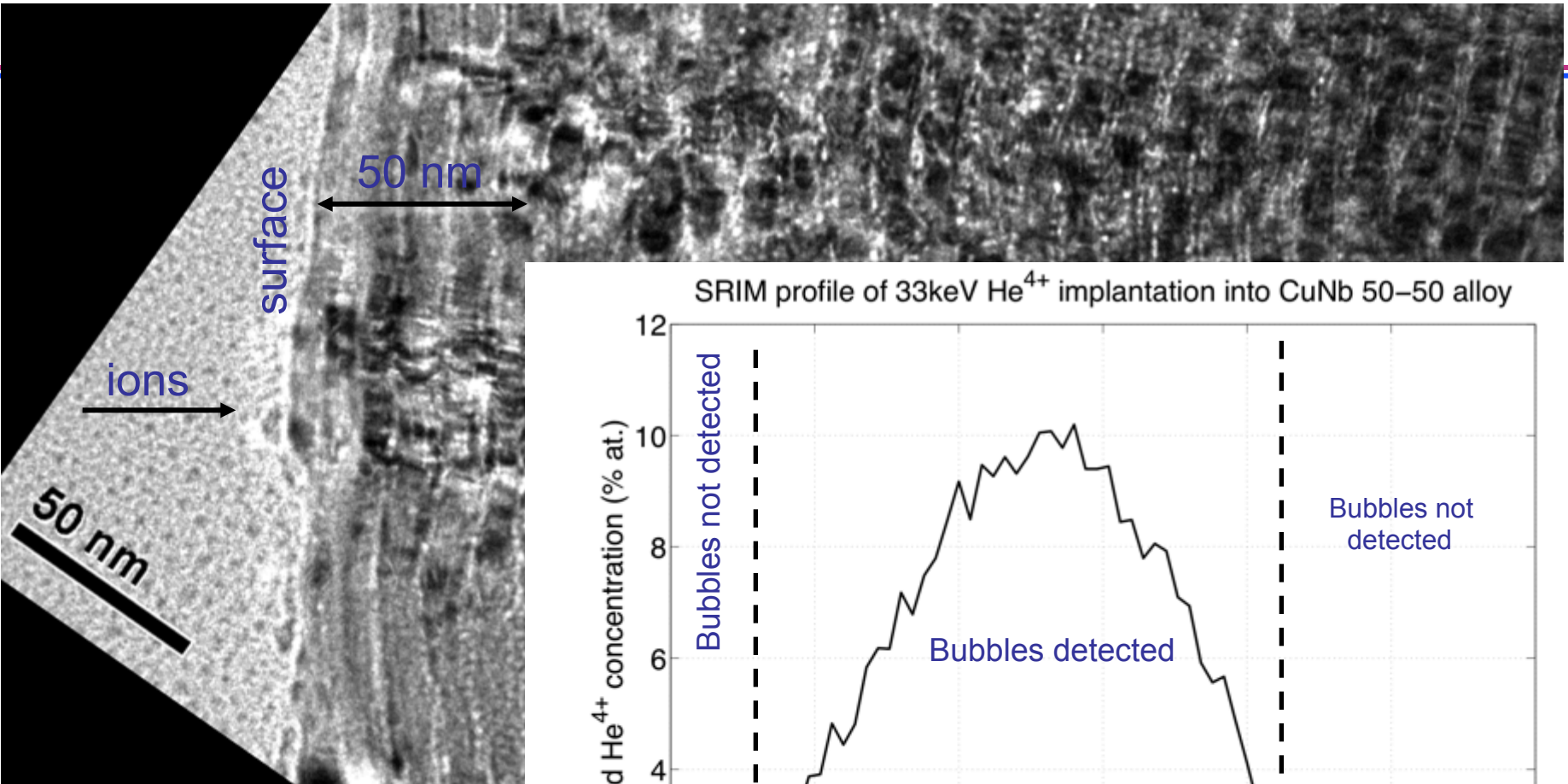
$$\begin{matrix} \{111\}_{\text{fcc}} \parallel \{110\}_{\text{bcc}} \\ \langle 110 \rangle_{\text{fcc}} \parallel \langle 100 \rangle_{\text{bcc}} \end{matrix}$$

Nishiyama-Wasserman orientation relationship

NW ($\rho_{\text{MDI}} = 0.1011 \text{ nm}^{-2}$)



The critical helium concentration at which bubbles are detected in TEM is measured by comparing concentration profile with under-focused TEM images

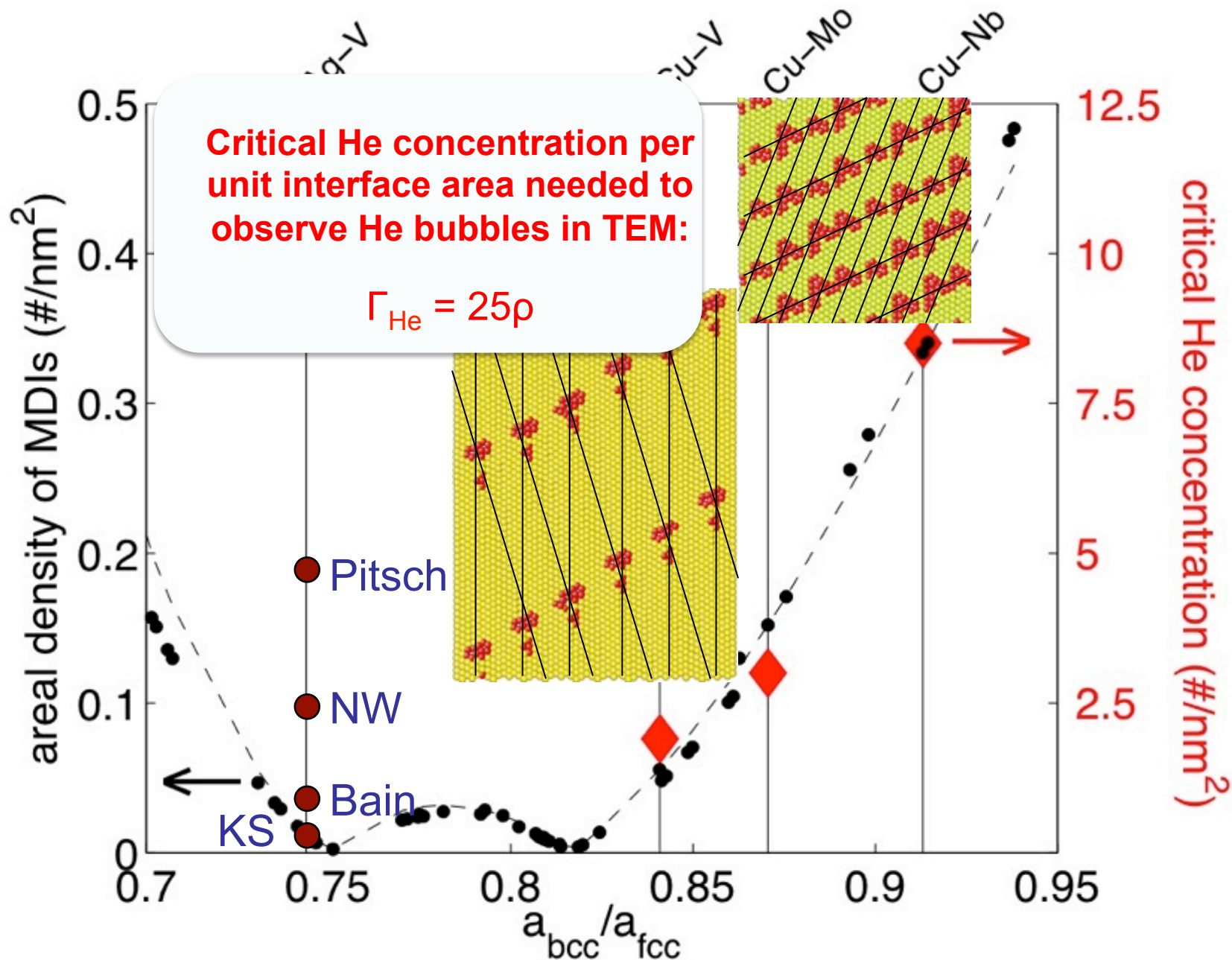


300 K He implantation

Energy: 33 keV

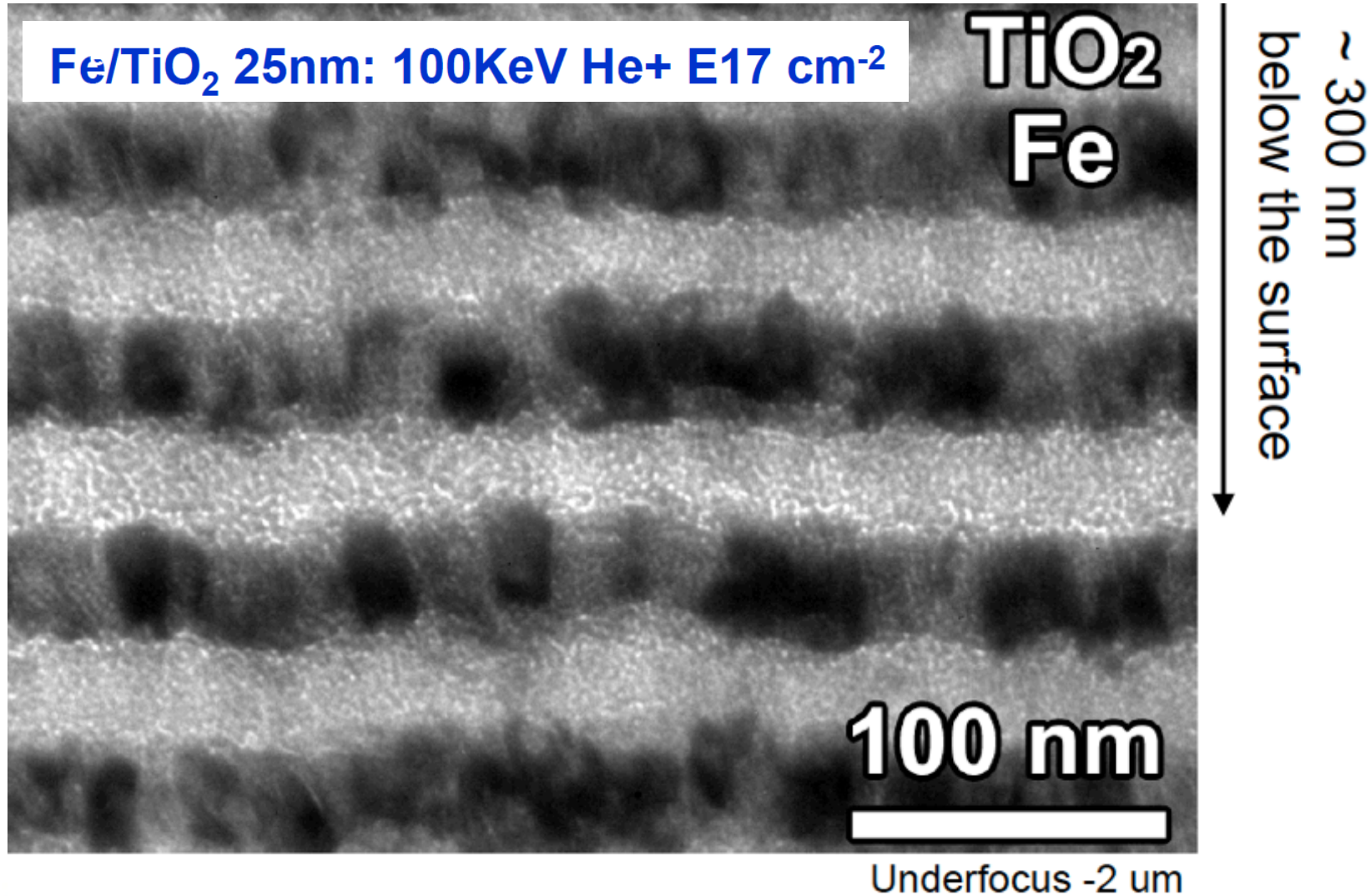
Dose: 1×10^{17} /cm²

Effect of Interface Structure on Helium Storage at Interfaces



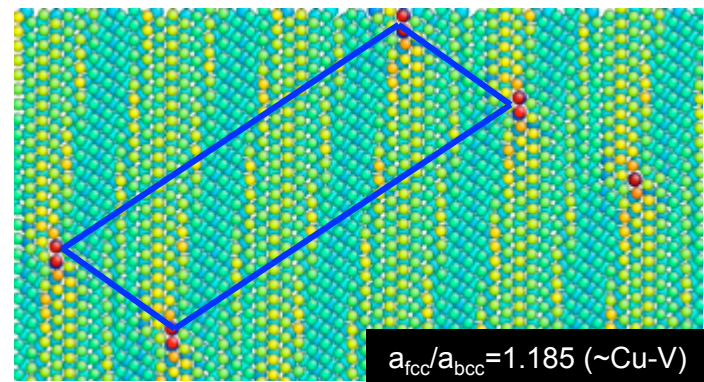
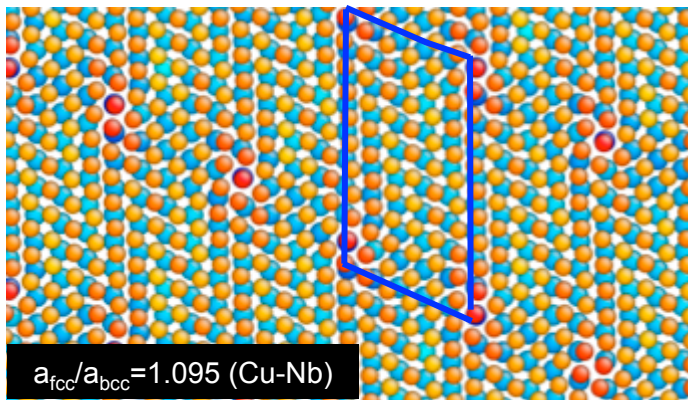
Model predictions are being validated on Fe-Oxide systems to enable predictions of interface design in ODS steels for helium trapping

O. Anderoglu, S.A. Maloy, A. Misra, *et al.*, unpublished



Final Summary

- *Atomic arrangements in the interface plane are different from bulk and can be tailored by geometry.*



- *By virtue of these unique atomic arrangements, interfaces can interact strongly with point and line defects (e.g., core delocalization).*
- *Unprecedented properties may be achieved in metal-ceramic nanocomposites through design of the atomic structure of interfaces.*